

Holographie numérique hétérodyne et thermoreflectance appliquées à des mesures thermiques haute résolution

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Thermographie résolue en temps : Virginie Moreau (post doctorante)

D. Fournier – LPEM, UPRA005, ESPCI

F. Joud, M. Gross, LKB, ENS

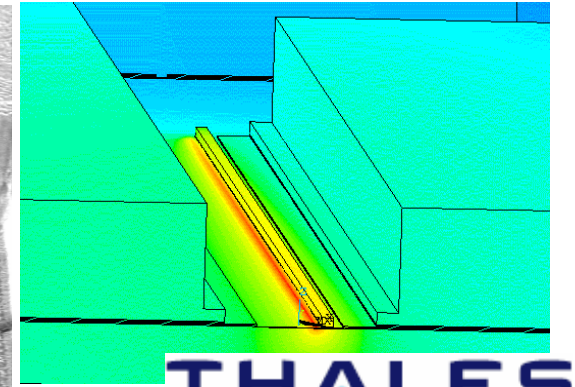
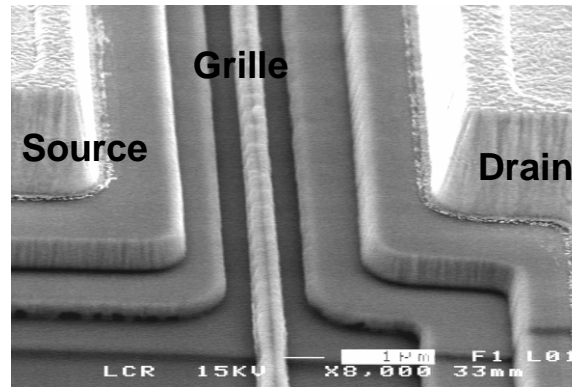
P. Bun, M. Coppey-Moisan, Inst. J. Monod

- 1- Thermoréflectance
résolue en temps
résolue en fréquence
- 2- Holographie numérique
imagerie de nanoparticules



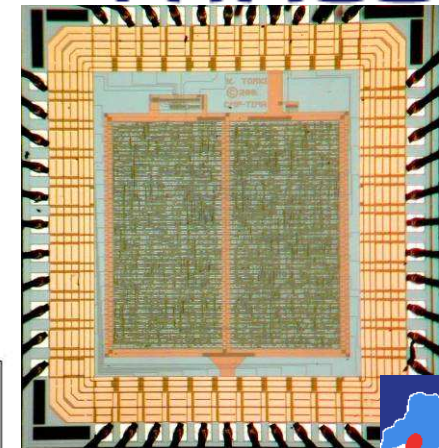
Quelques problèmes thermiques en électronique intégrée / optronique

- **Transistors de puissance** :
échauffement dans la zone grille - drain

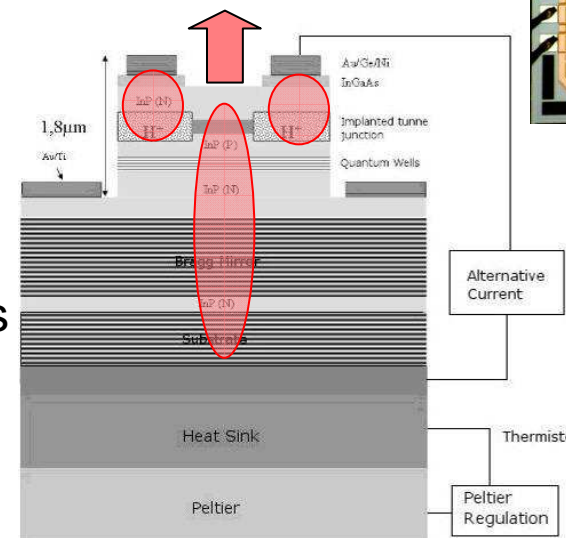


- **MOS** : Courant transitoire lors du basculement

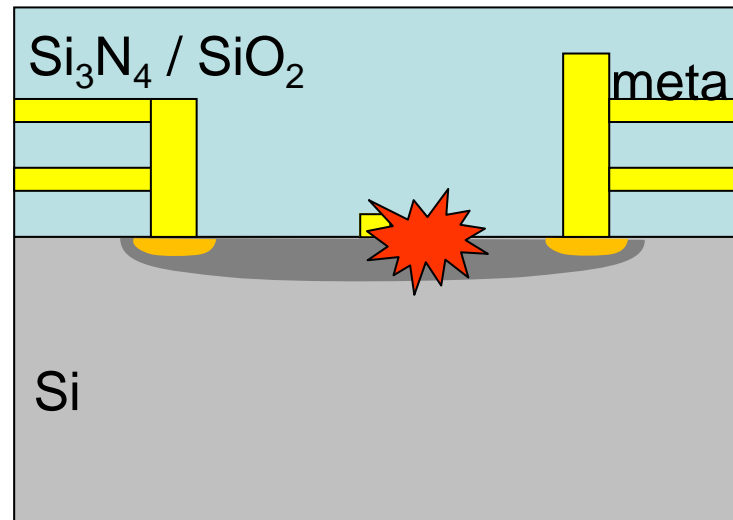
→ augmente avec la fréquence



- **Diodes laser** :
- Effet Joule à l'injection
- Absorption du faisceau dans les couches



Détection de points chauds / imagerie de température Dans les circuits intégrés



- températures élevées
- petites échelles
- Dispositifs 3D

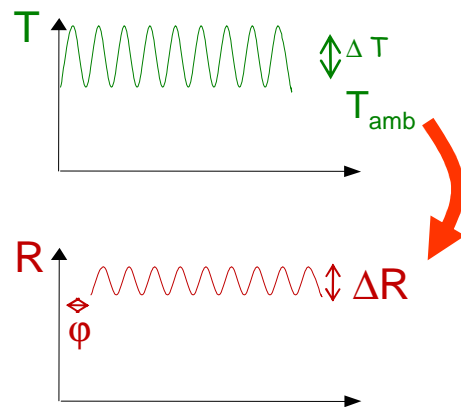
Photoreflectance ou Thermoreflectance avec une sonde laser

Le coefficient de réflexion d'une surface dépend de sa température :

$$\Delta R = \frac{\partial R}{\partial T} \Delta T$$

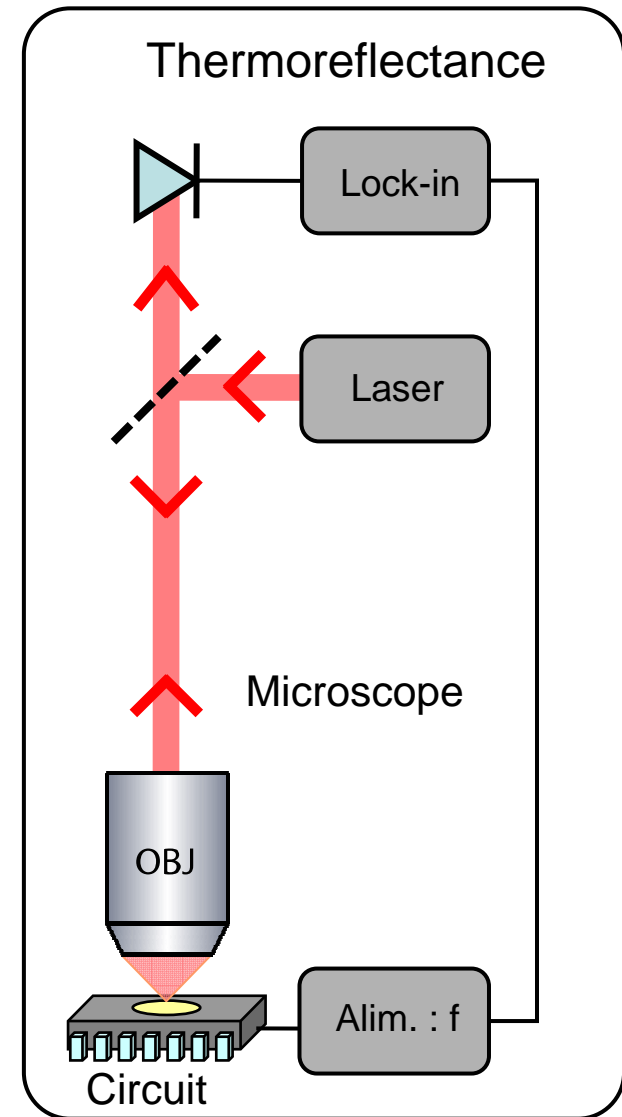
↓

10^{-3} à 10^{-5}

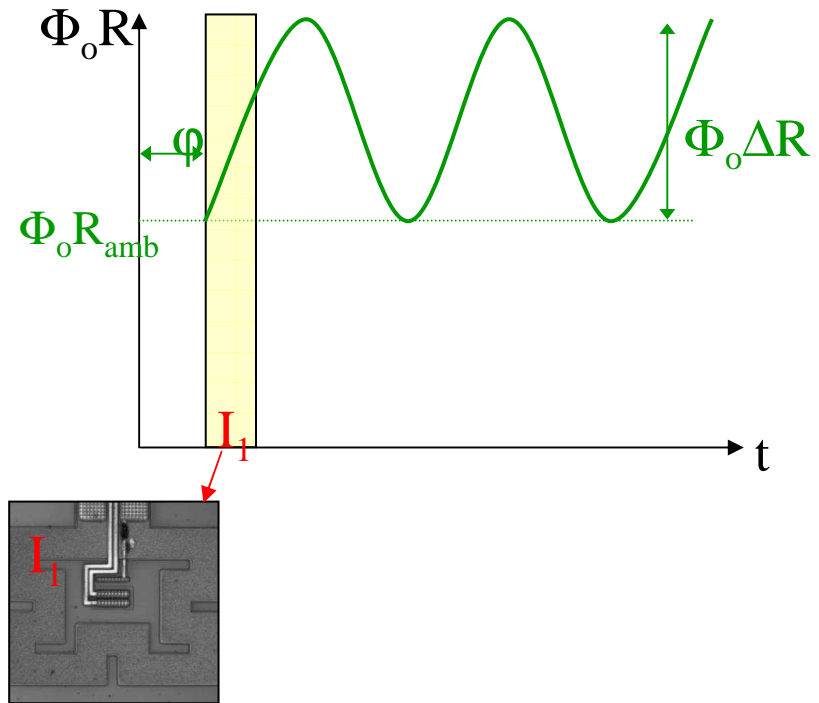
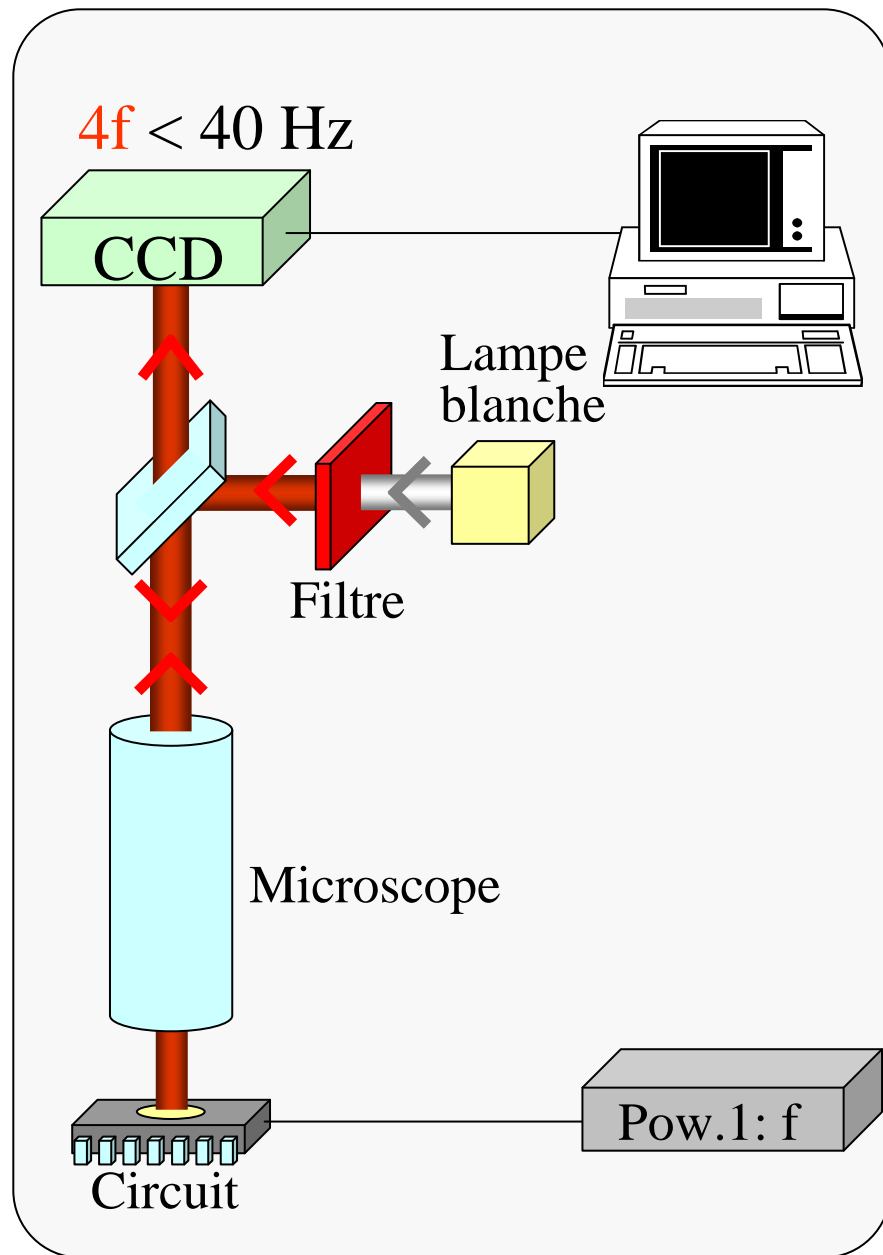


Mesure de ΔR à n'importe quelle longueur d'onde

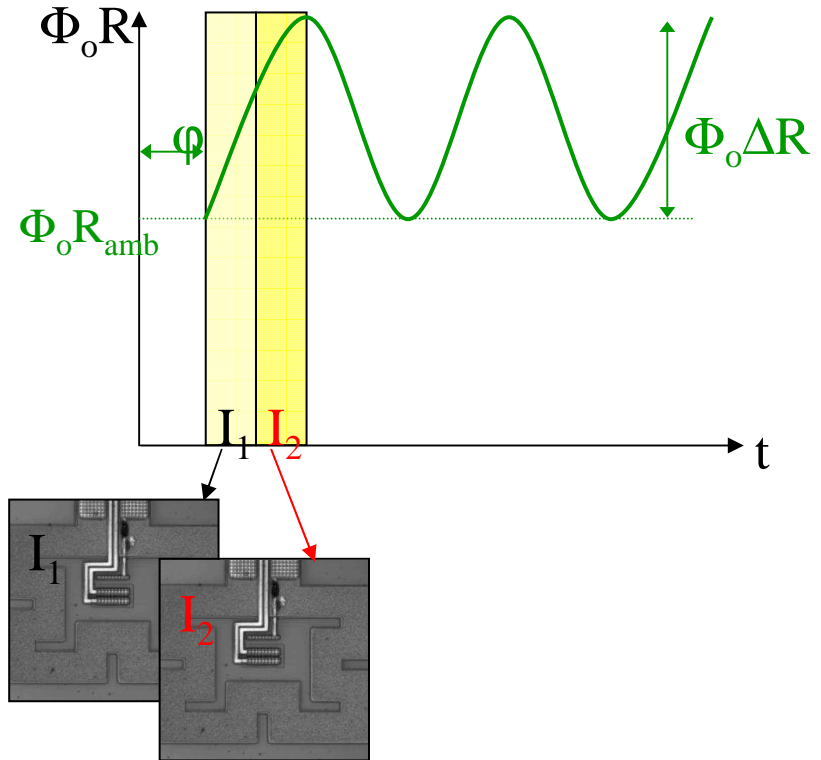
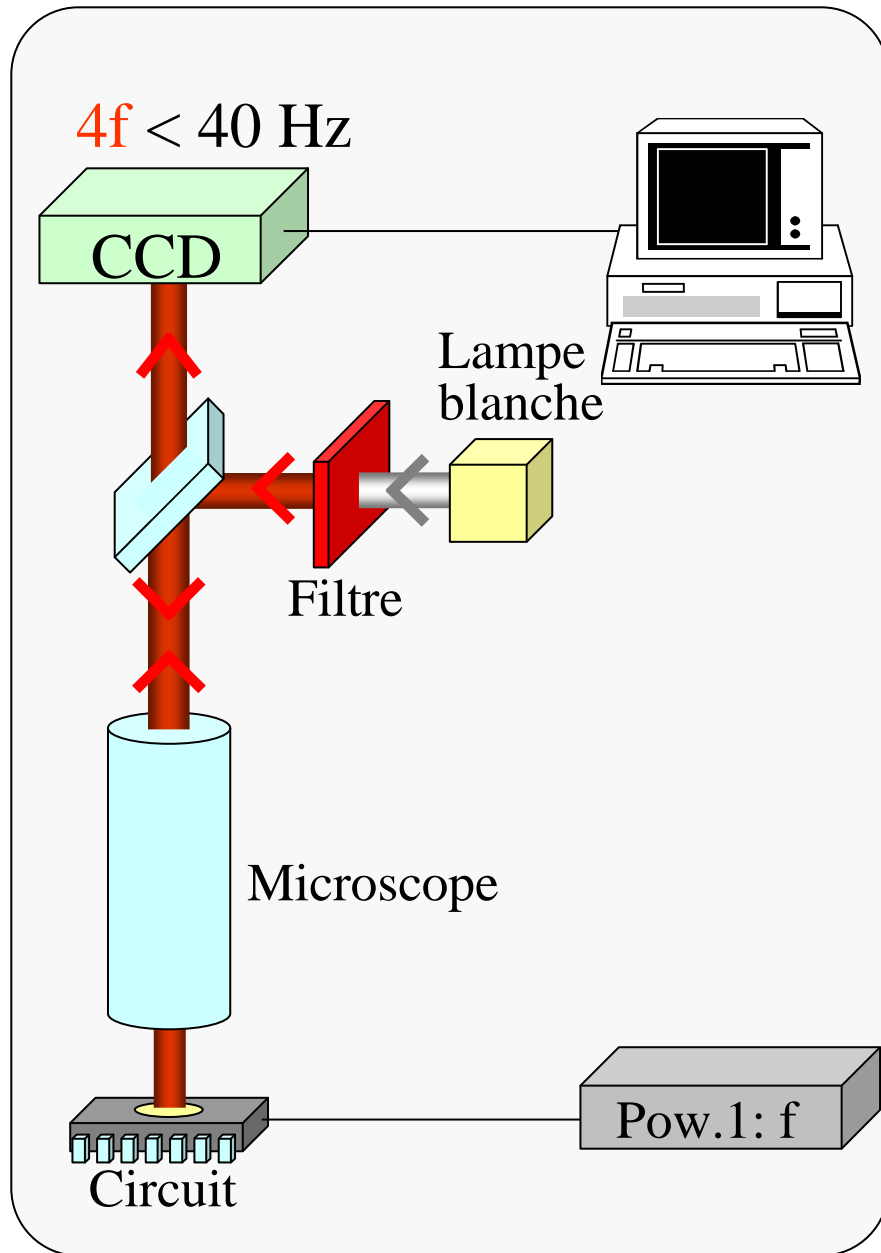
➡ Variation de temperature ΔT



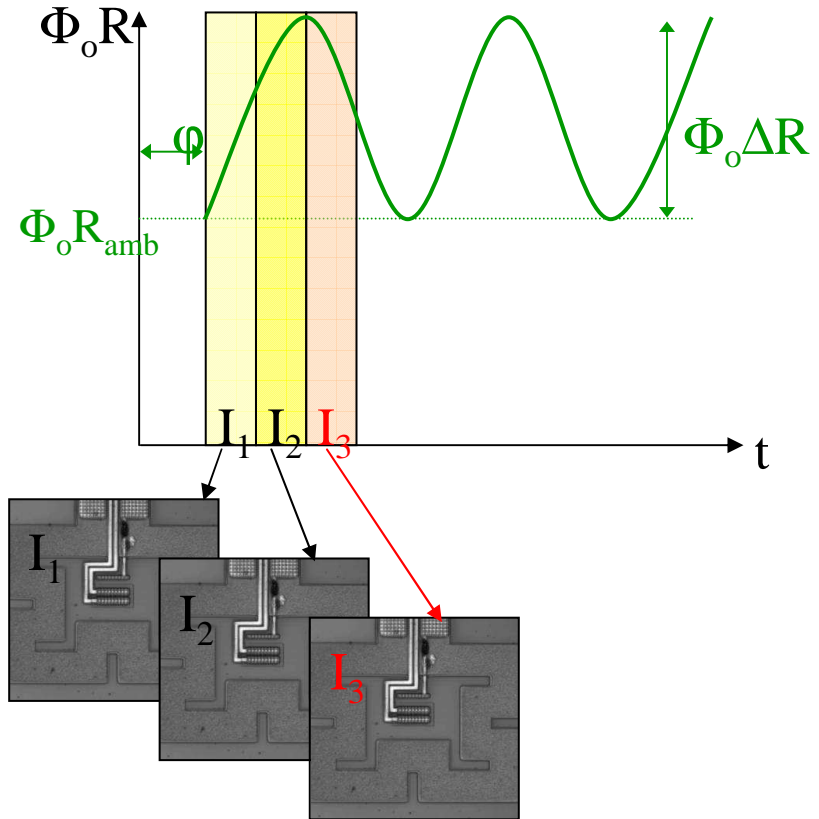
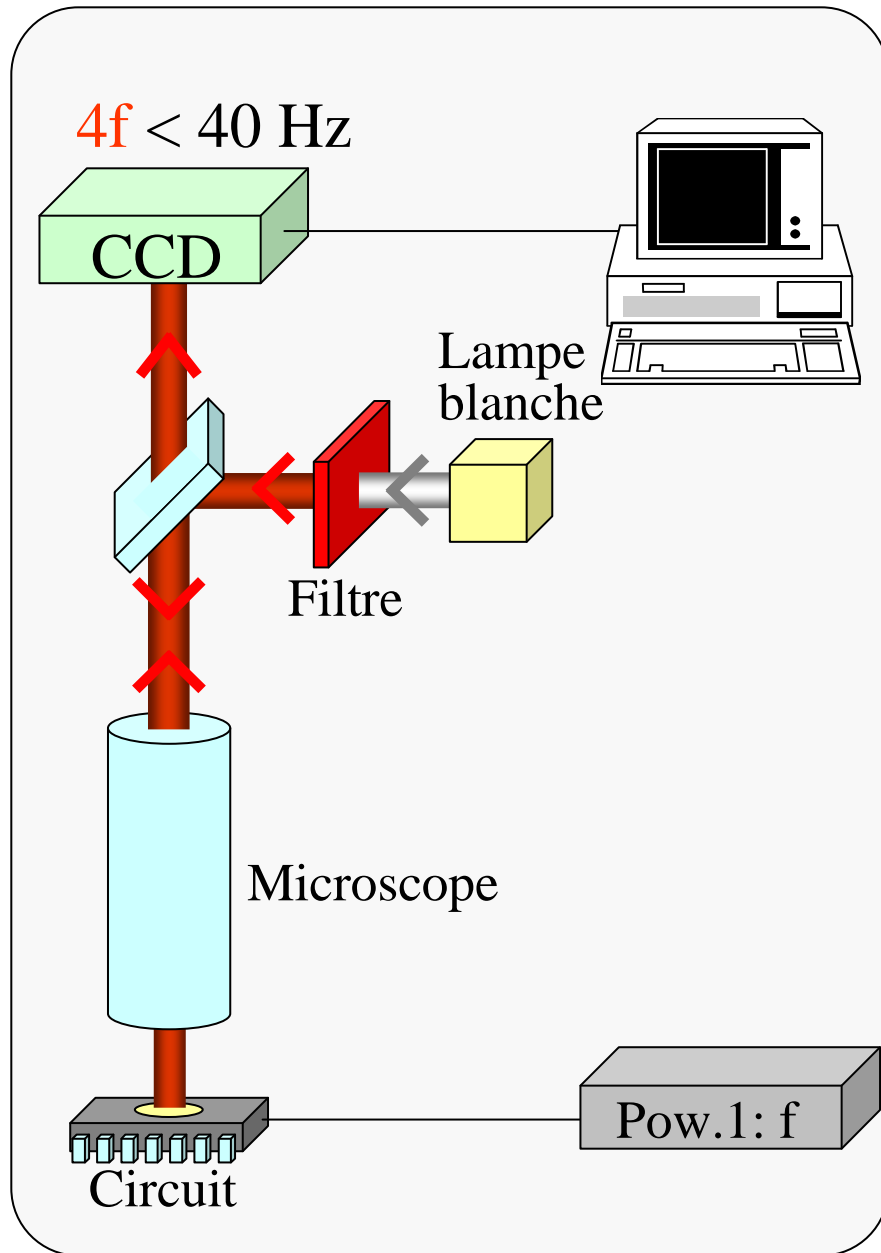
Imagerie de thermoreflectance CCD



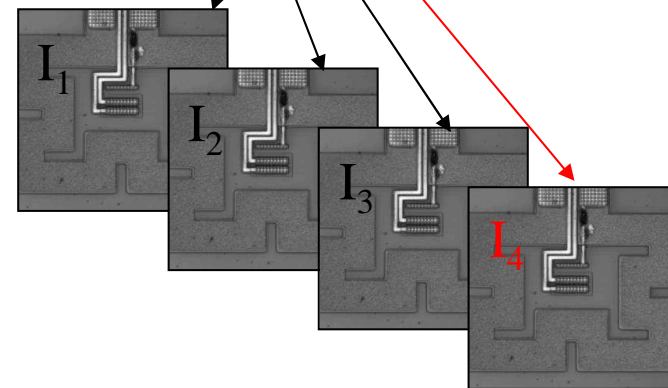
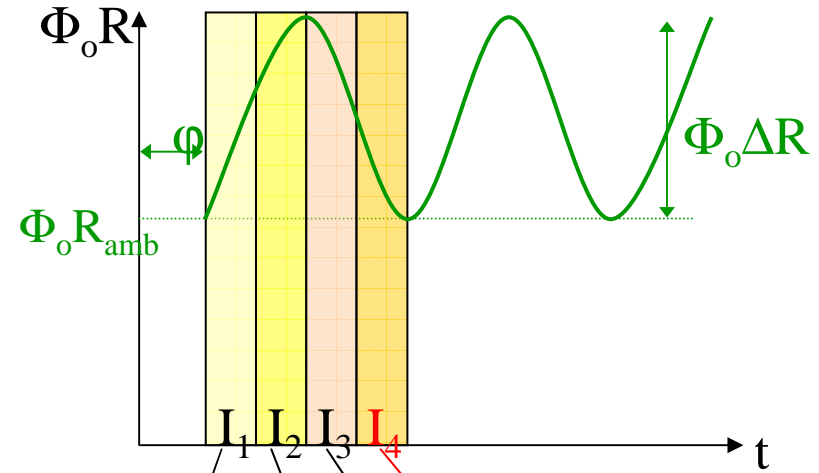
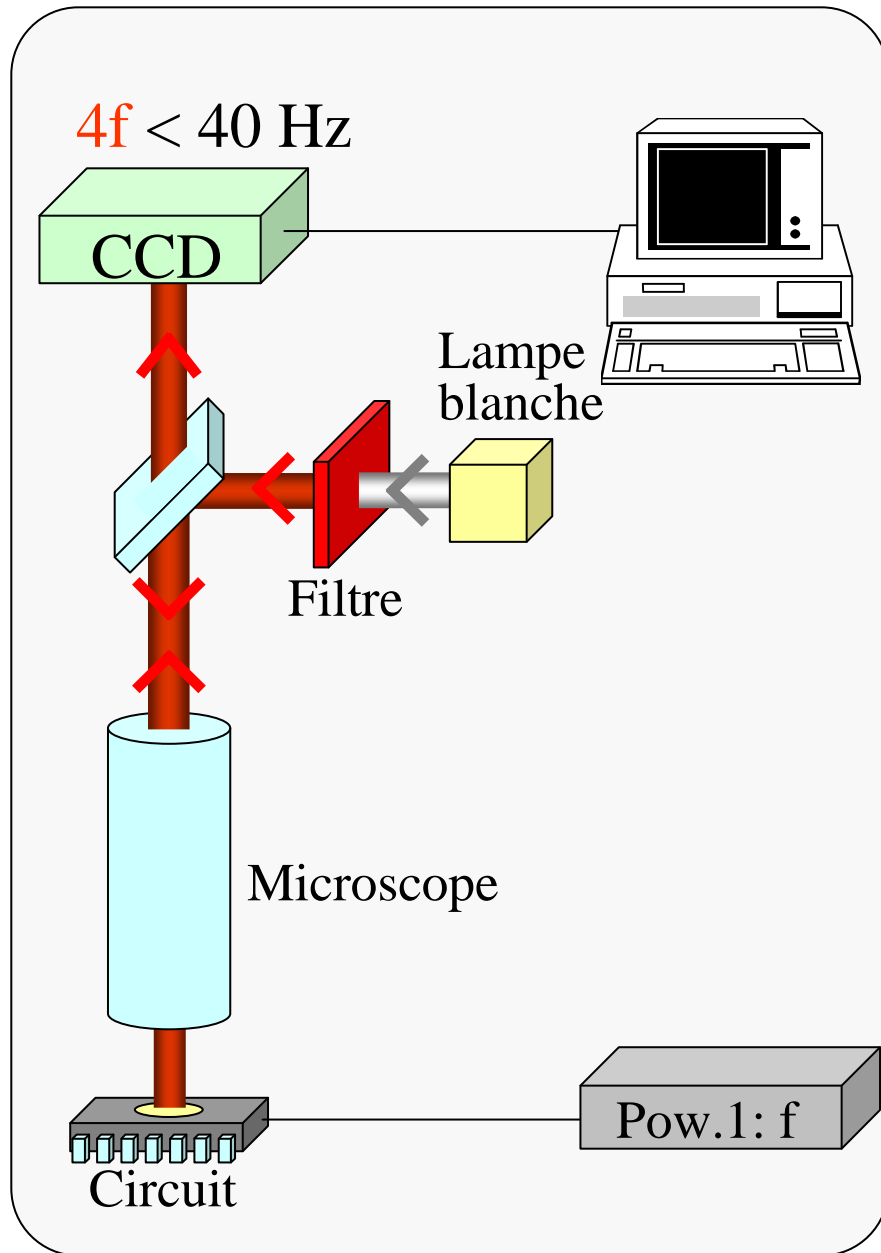
Imagerie de thermoreflectance CCD



Imagerie de thermoreflectance CCD

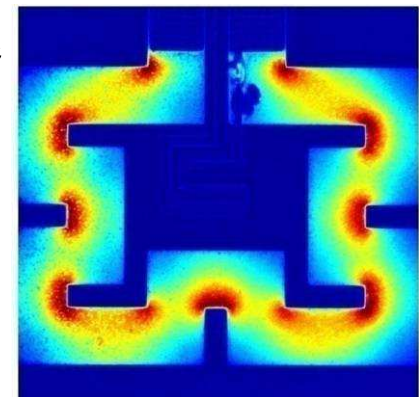


Imagerie de thermoreflectance CCD



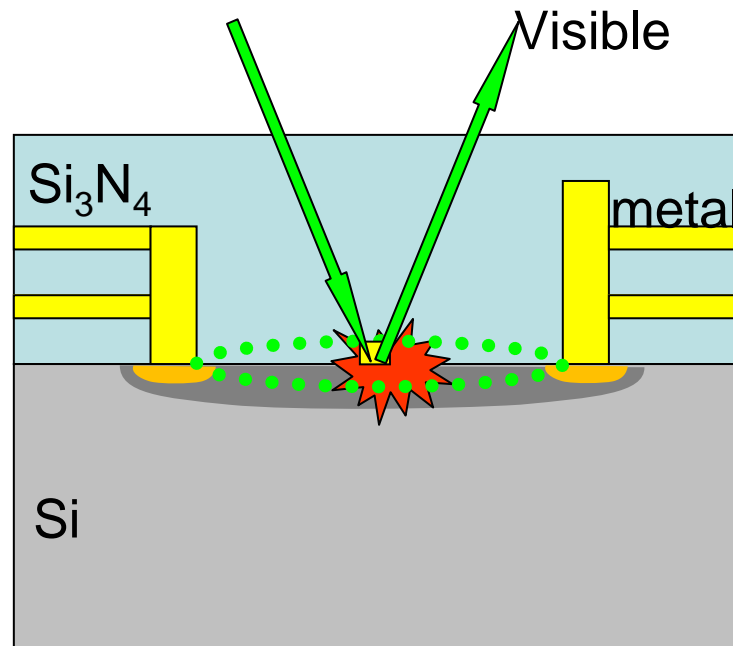
Amplitude
(ou phase)

$$|\Phi_0 \Delta R| = \sqrt{\frac{(I_1 - I_3)^2 + (I_2 - I_4)^2}{4}}$$

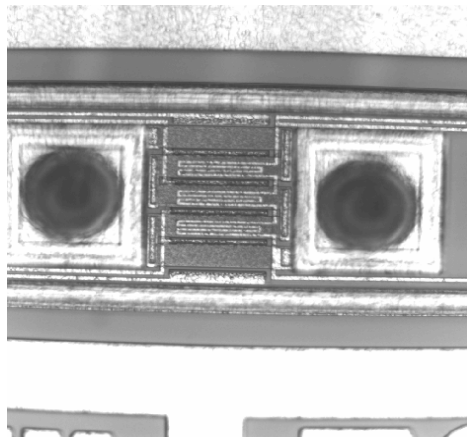
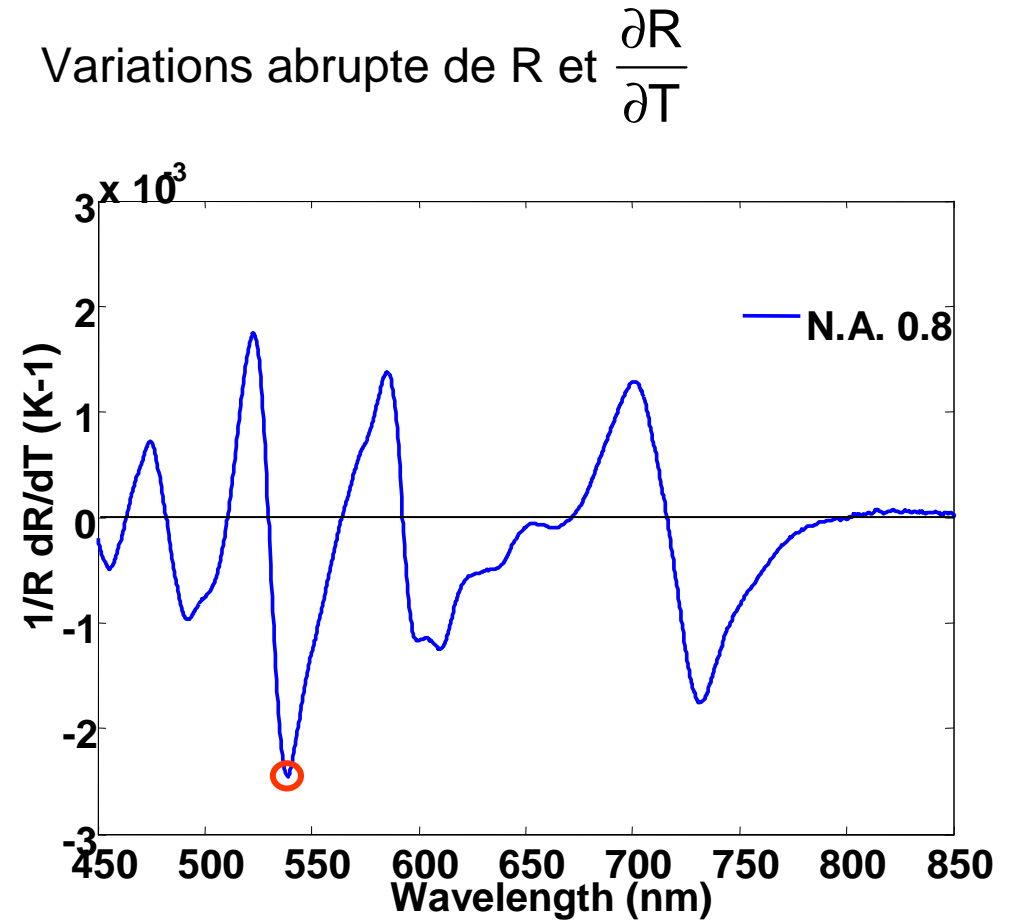
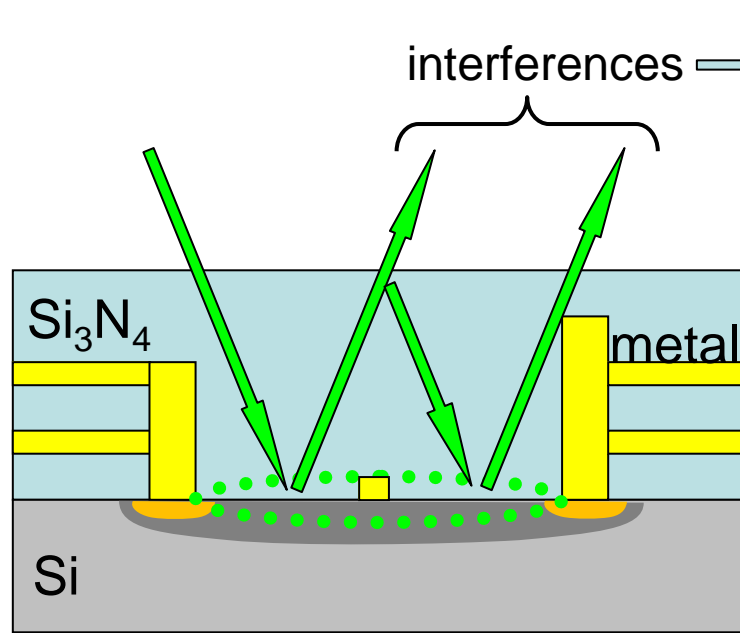


1

Thermoreflectance sous illumination visible

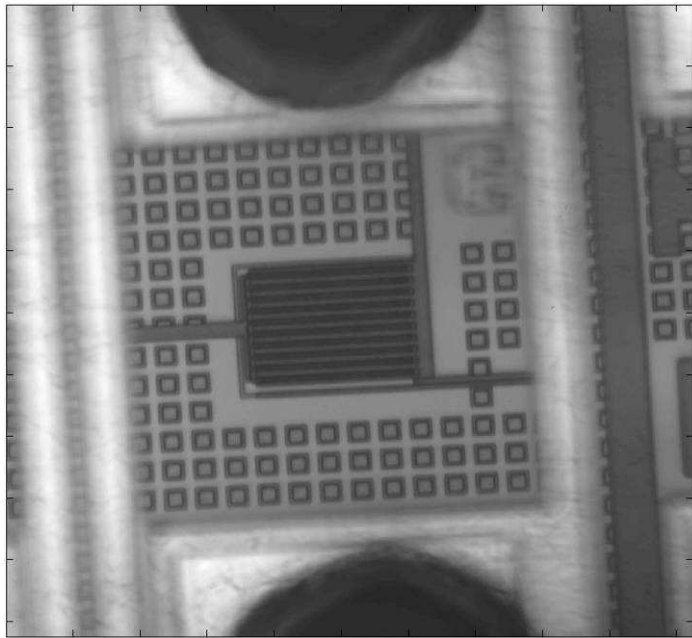


Interférences et thermoreflectance



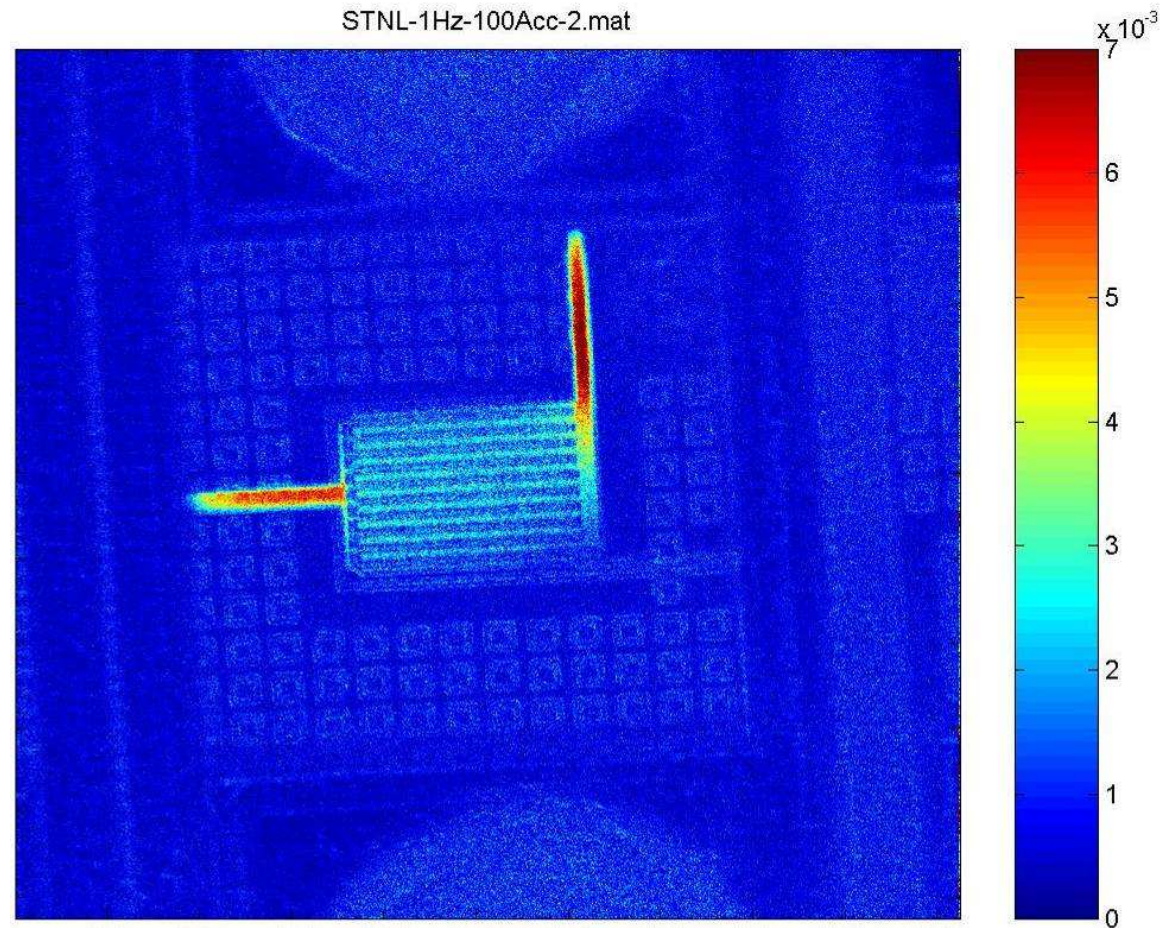
Poly Si resistors / Si₃N₄ / polyamide
 0.12 mW.μm² ΔT_{surf.}=100°C
 1 min integration

Réseau de transistors (ST Microelectronics)



125 μm

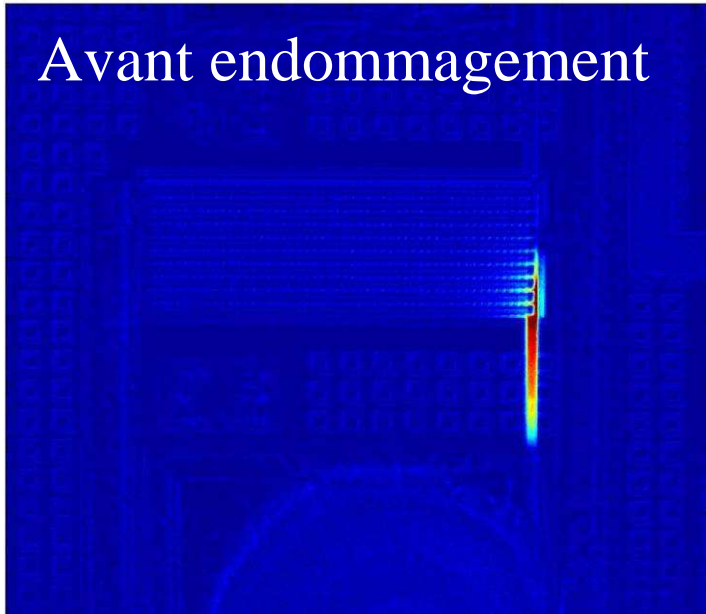
Structure sans fuites:
Pas de points chauds



Réseau de transistors (ST Microelectronics)



Avant endommagement



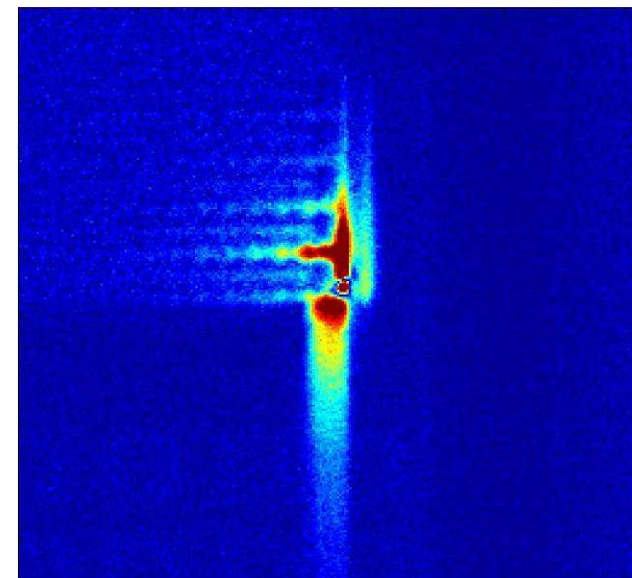
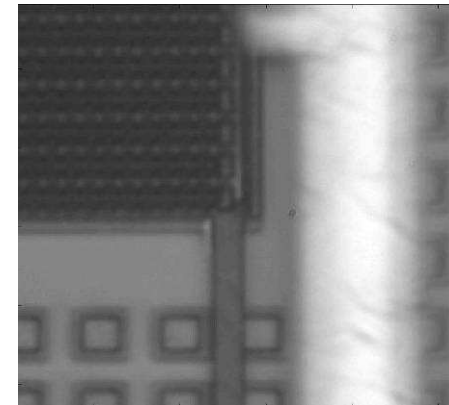
Après endommagement



125 μm

Resolution spatiale < 340 nm

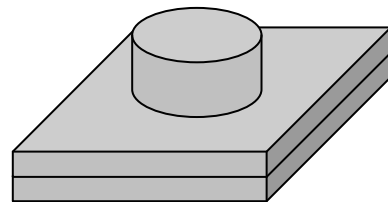
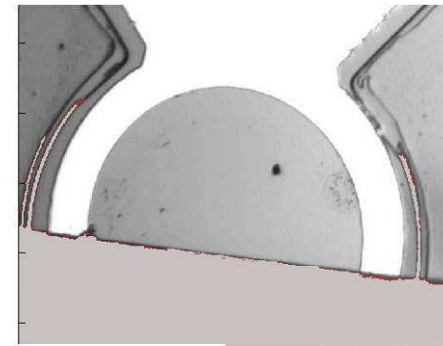
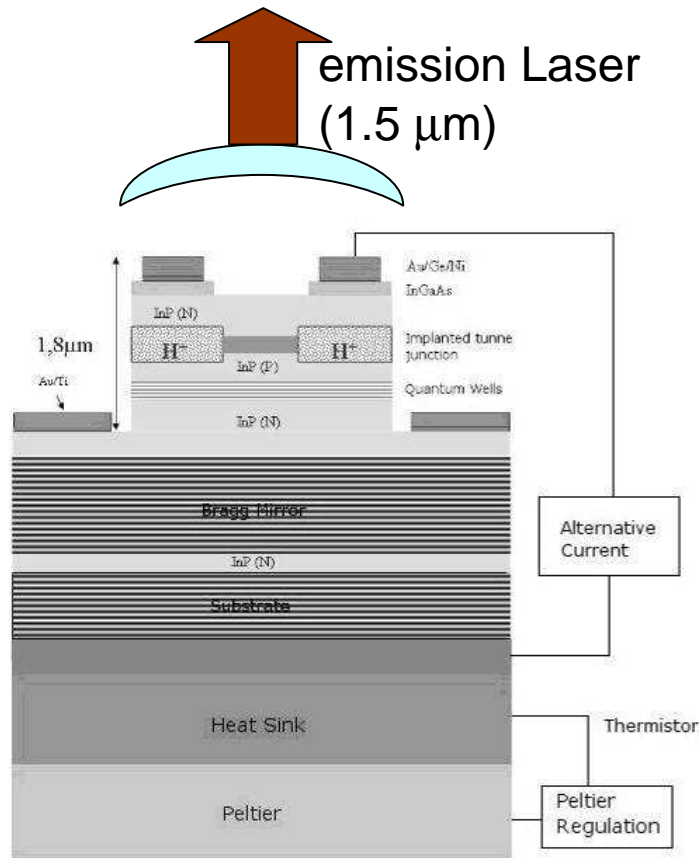
Imagerie à travers 6 μm de diélectrique



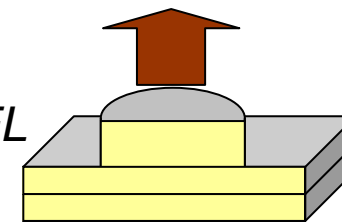
13 μm

Vertical Cavity Surface Emission Lasers (VCSELs)

M Bardoux, ESPCI, S. Bouchoule, A. Bousseksou, LPN

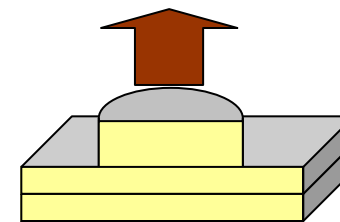
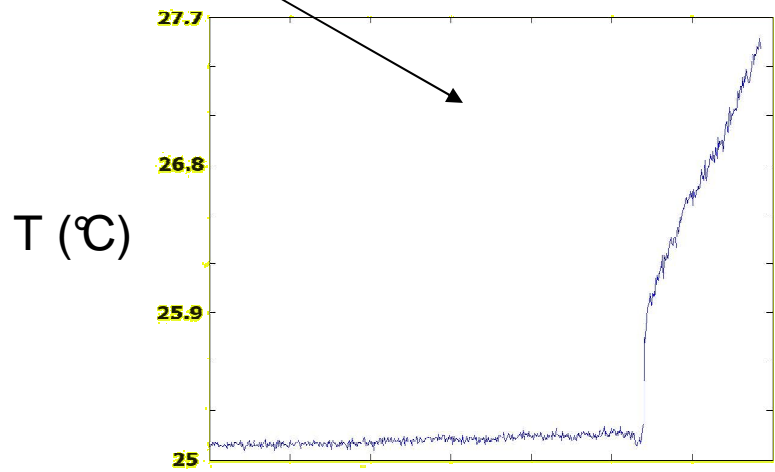
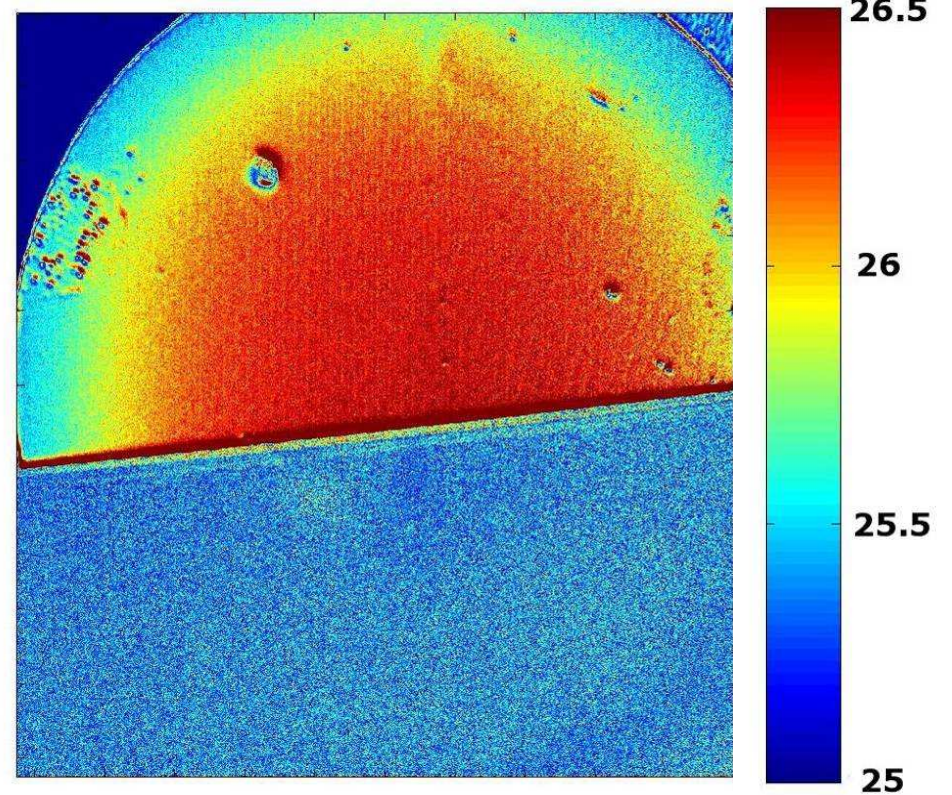
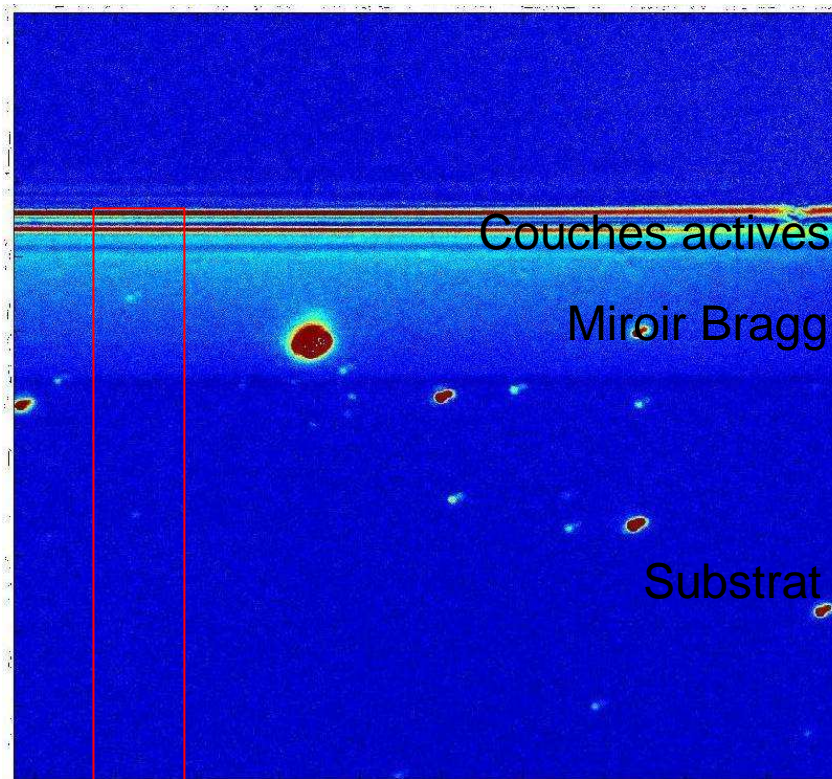


Clivage du VCSEL

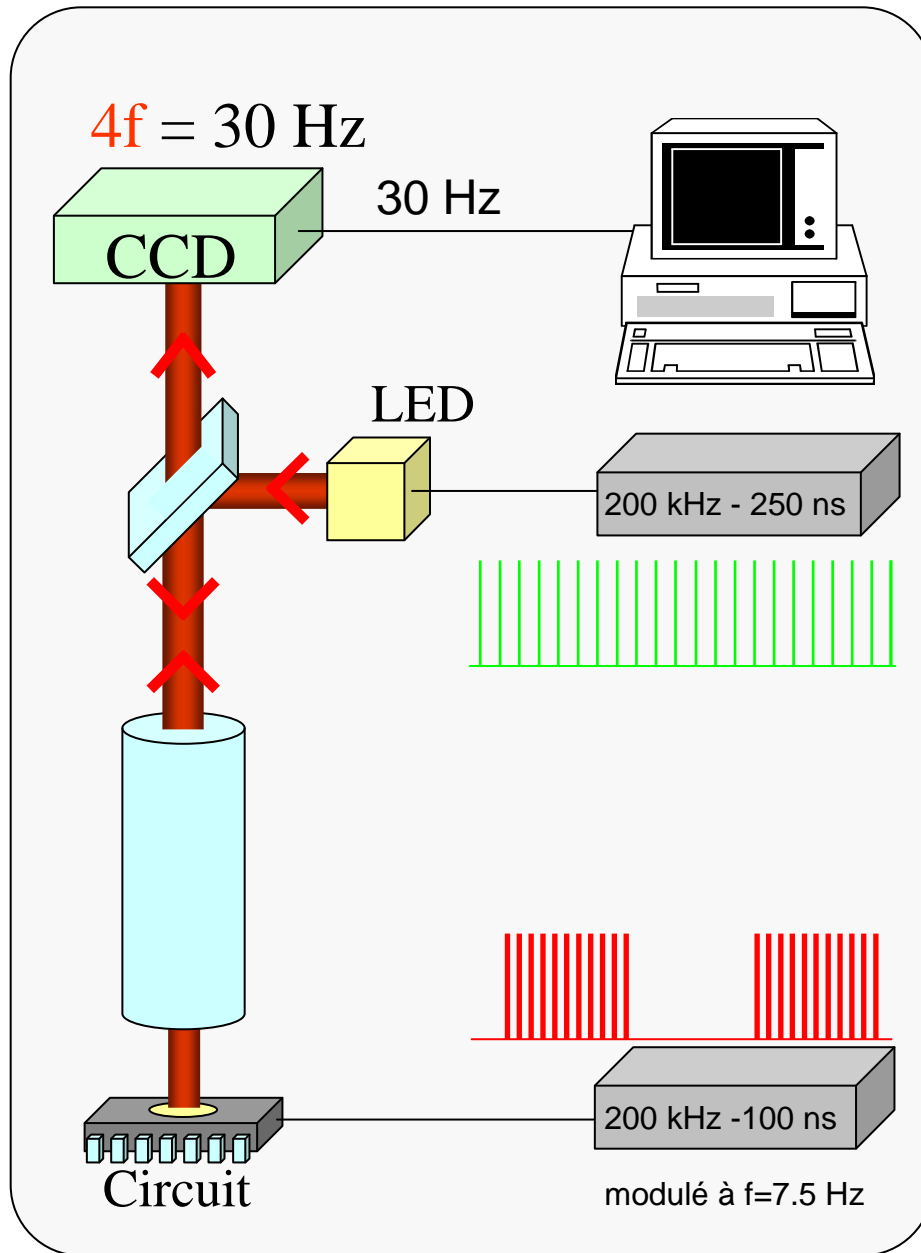


*distribution
Verticale de la temperature*

Vue de côté (substrat, mirror, active layers) Vue de dessus (facette d'émission) $T(\text{°C})$



Thermoreflectance résolue en temps



Impulsions lumineuses : 250 ns

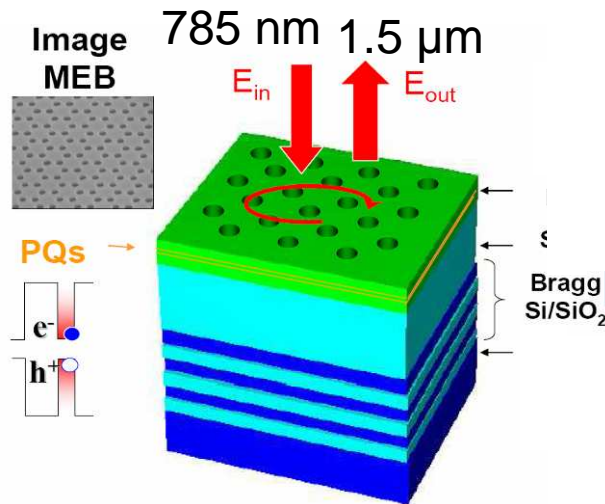
= Résolution temporelle

Thermoréflectance résolue en temps

V. Moreau

Collaboration M. Brunstein, A. Yacomotti, R. Raj, A. Levenson, LPN Marcoussis

Photonic crystal active structures emitting at $1.55 \mu\text{m}$



Active structures

Quantum wells
InGaAs/InP

Quantum dots
InAsP/InP

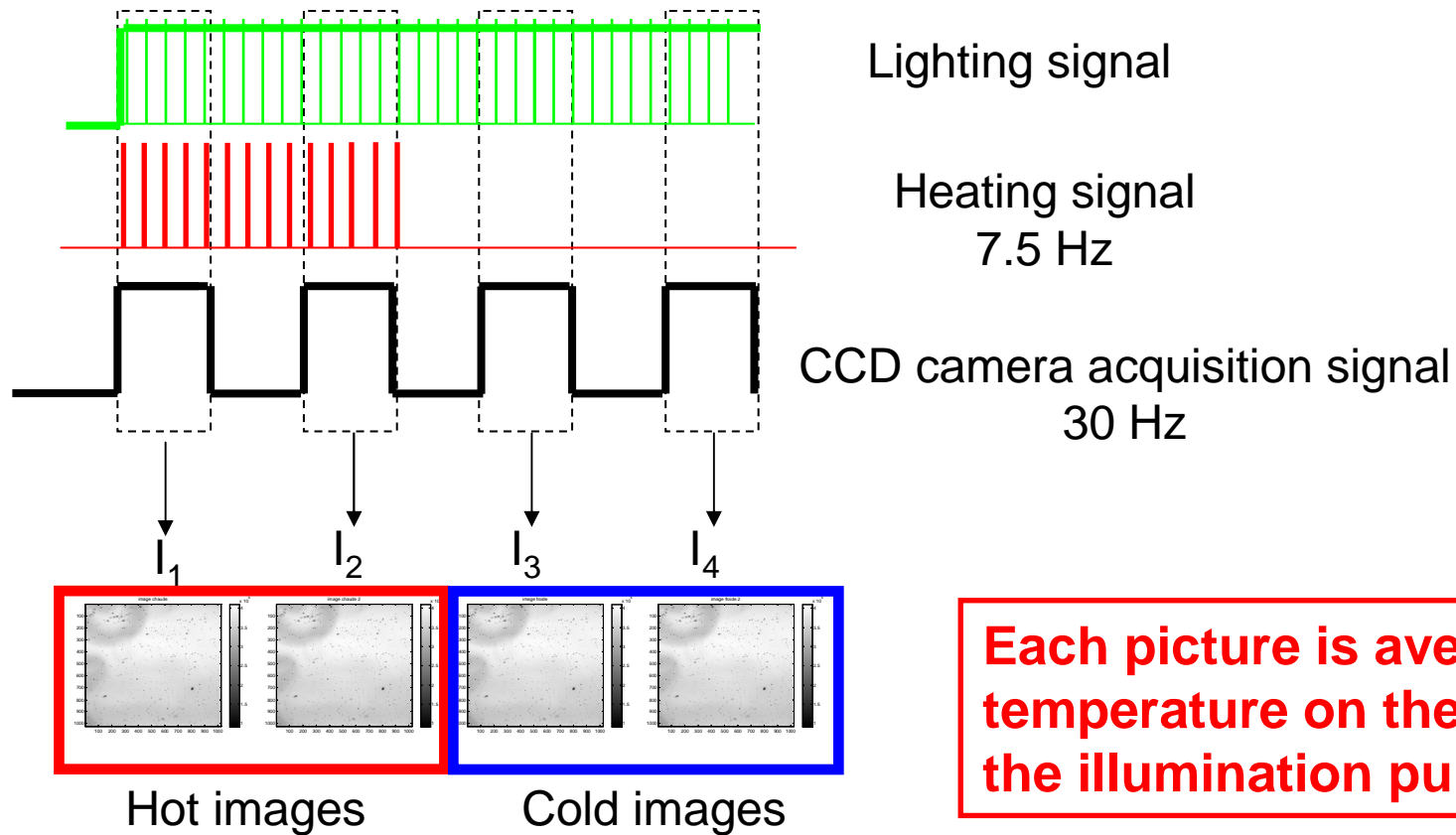
Optical pumping

- For many applications, such as laser effect or non-linear studies, the pump can be intense and the heating should be managed.
- In other cases, these effects can be useful : thermo-optical switches



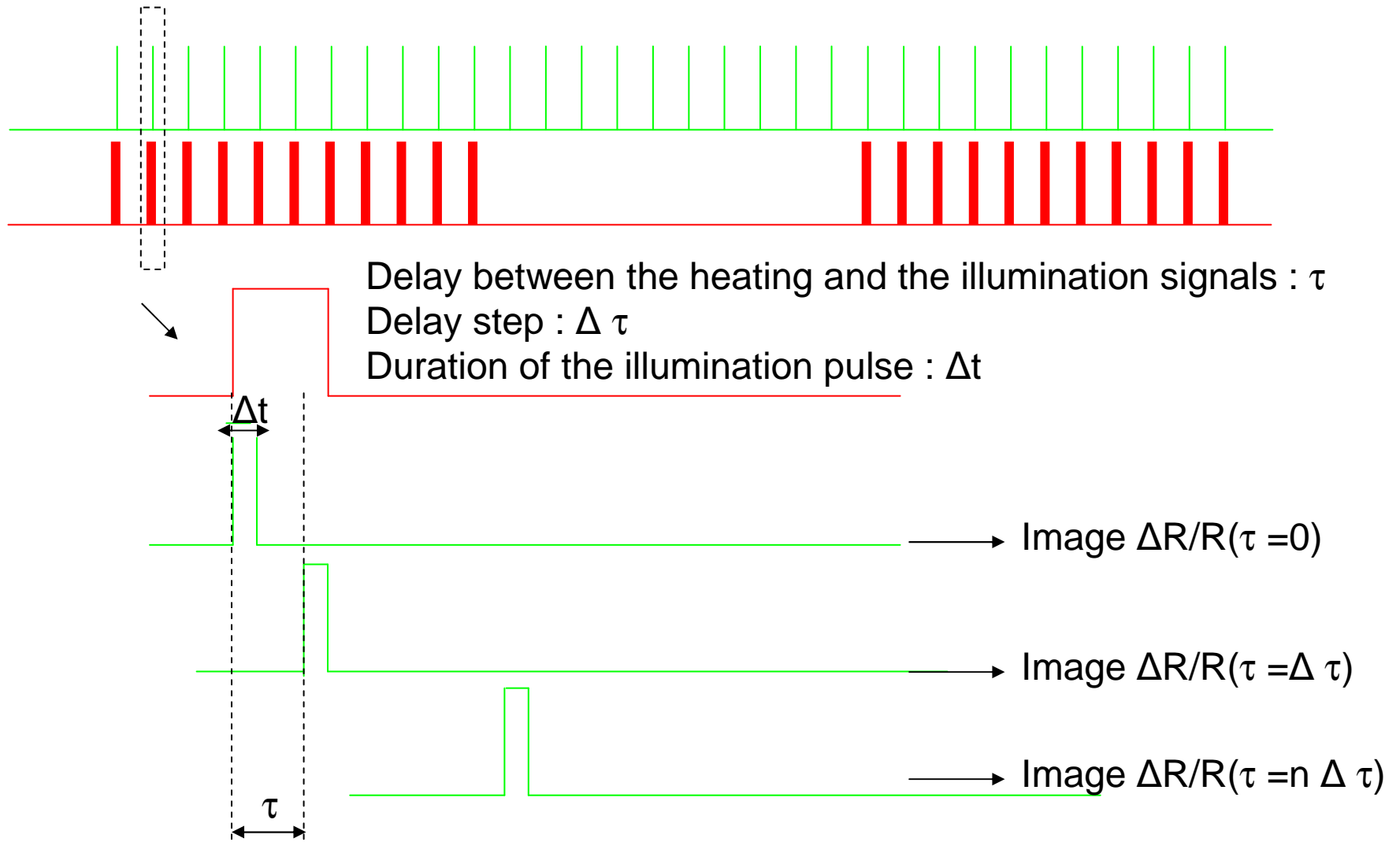
Need for a non invasive spatio- temporal high resolved system for temperature measurement

Transient thermoreflectance principle : stroboscopic principle



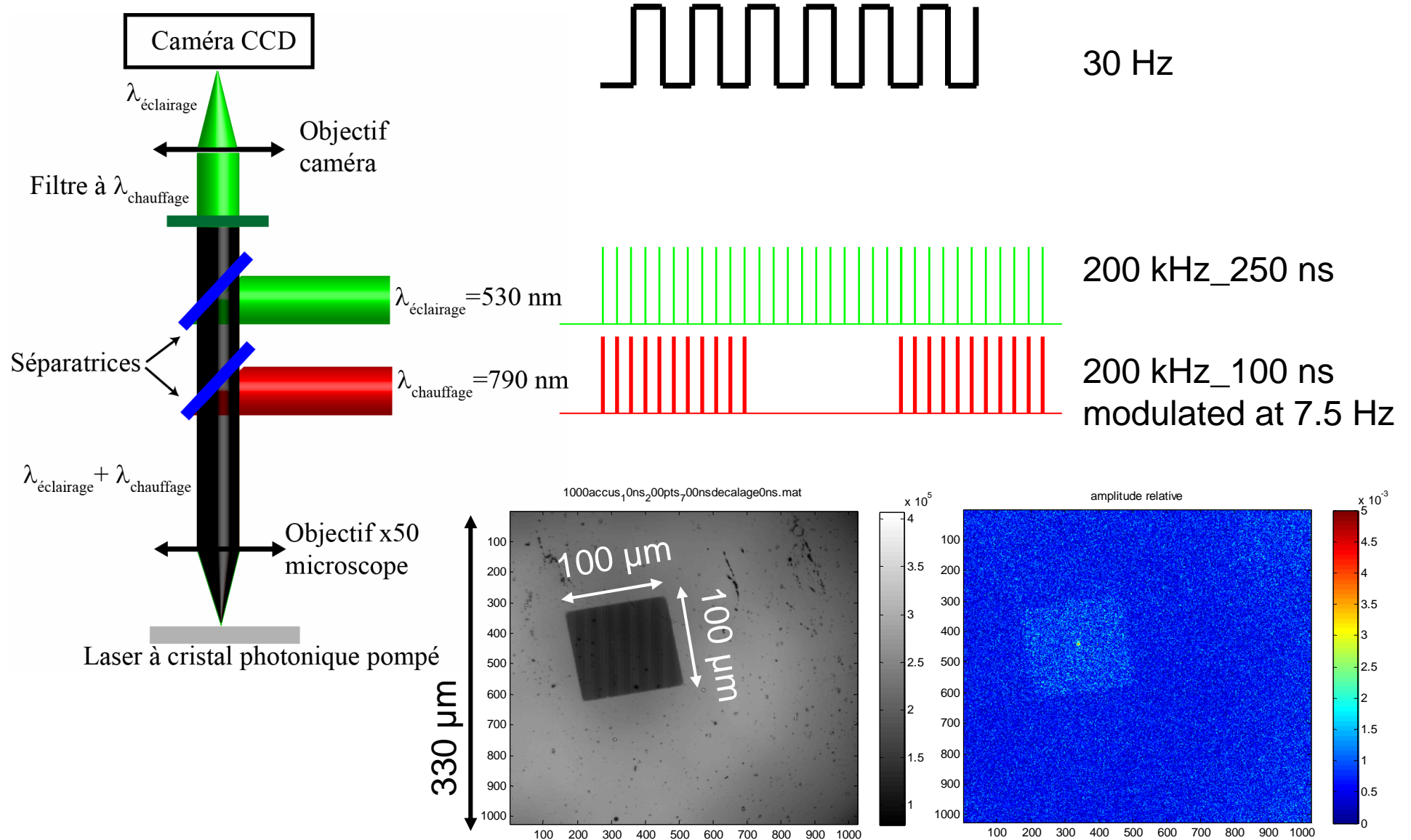
$$\begin{matrix} \text{L-shaped arrow} & \rightarrow & \frac{(I_1 - I_3) + i(I_2 - I_4)}{(I_1 + I_2 + I_3 + I_4)/4} & \rightarrow & \Delta R / \langle R \rangle \end{matrix}$$

Transient thermoreflectance principle

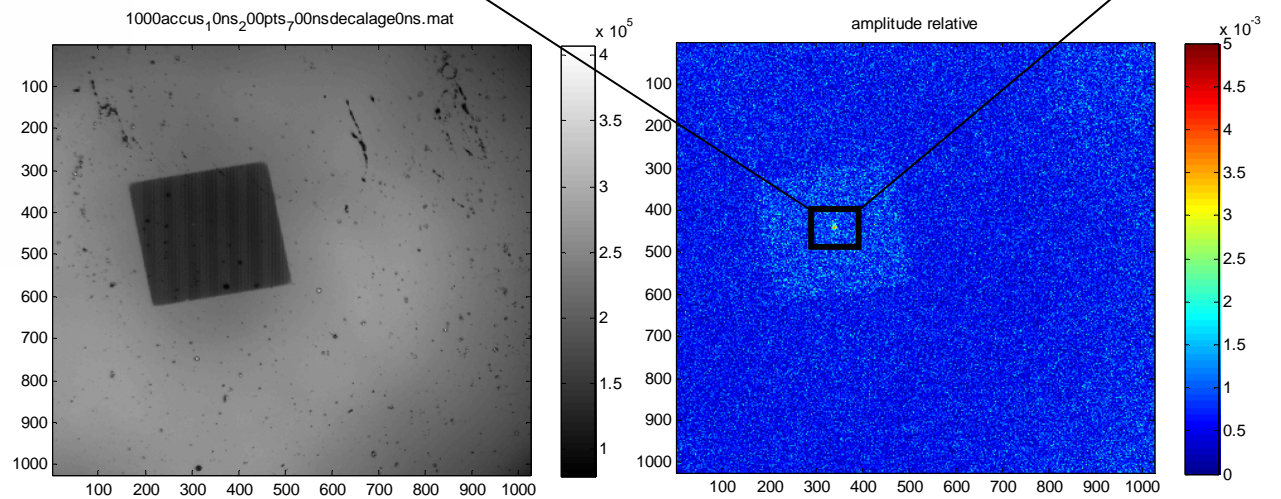
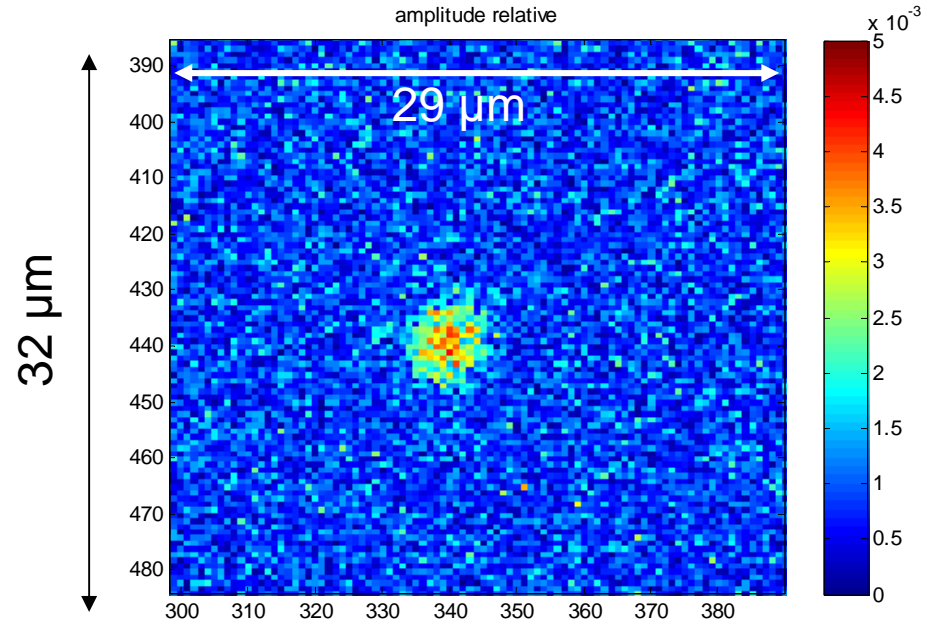
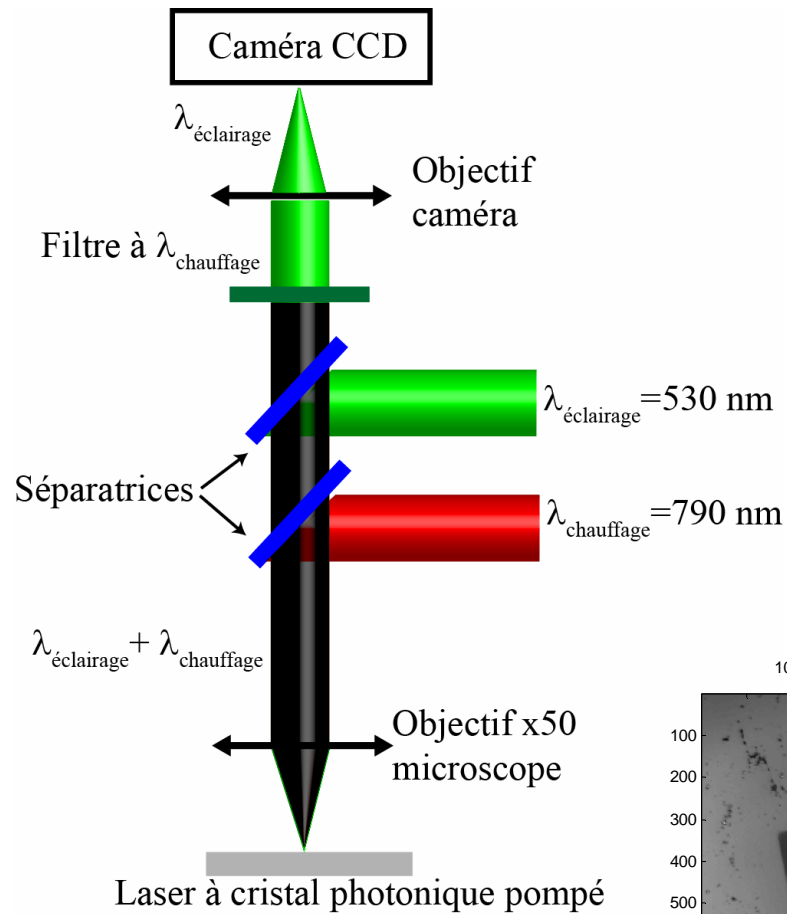


$\Delta R/R(\tau)$ gives the average temperature on a duration Δt

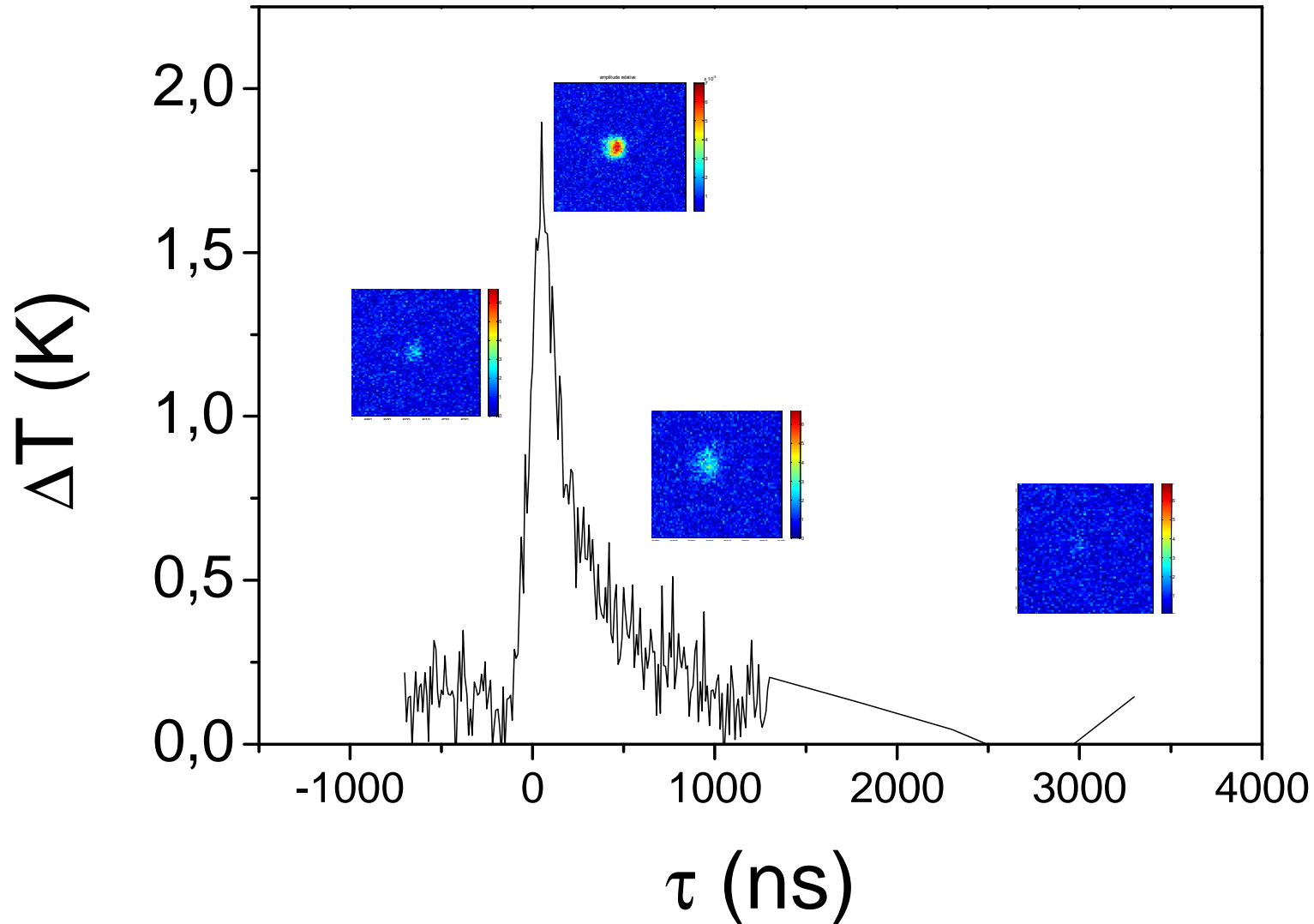
Transient thermoreflectance on a photonic crystal laser



Transient thermoreflectance on a photonic crystal laser

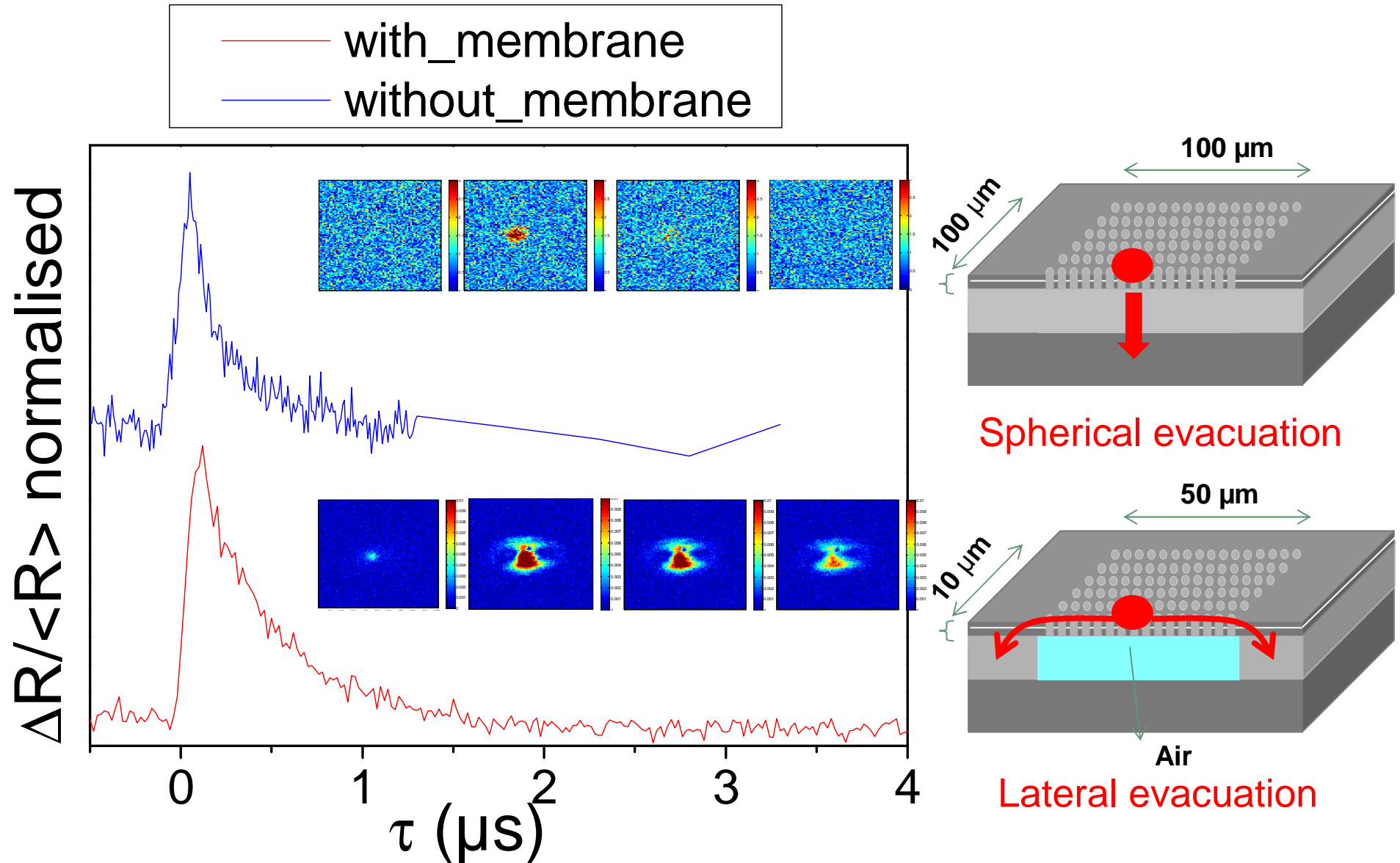


Spatio-temporal distribution of temperature on 2D photonic crystal lasers



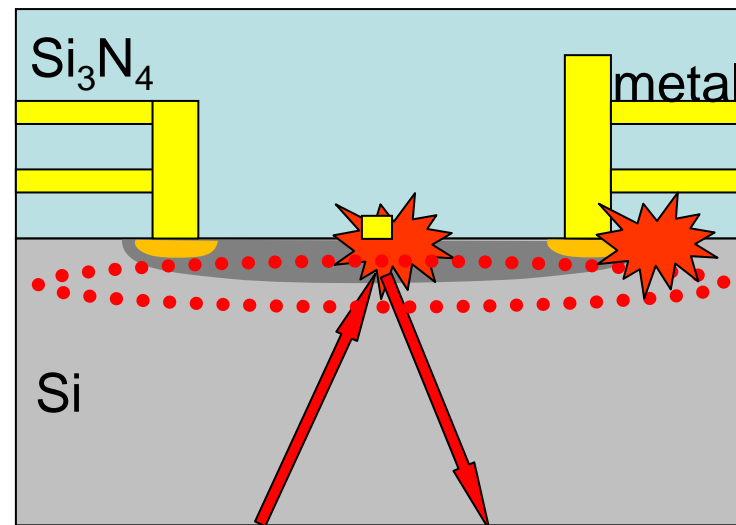
Dissipation time < 1 μ s and increase of temperature around 2 K

Different mechanisms of thermal evacuation



2

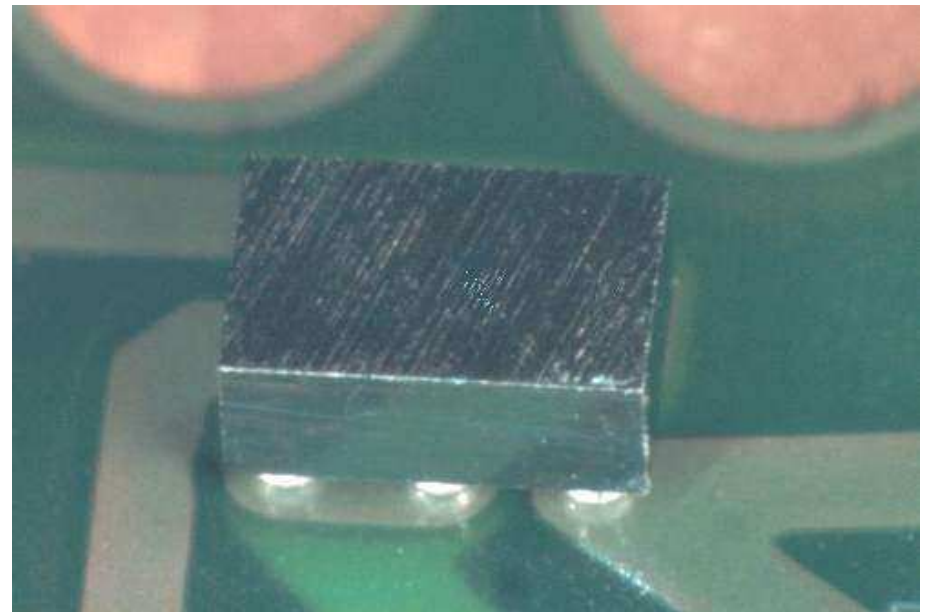
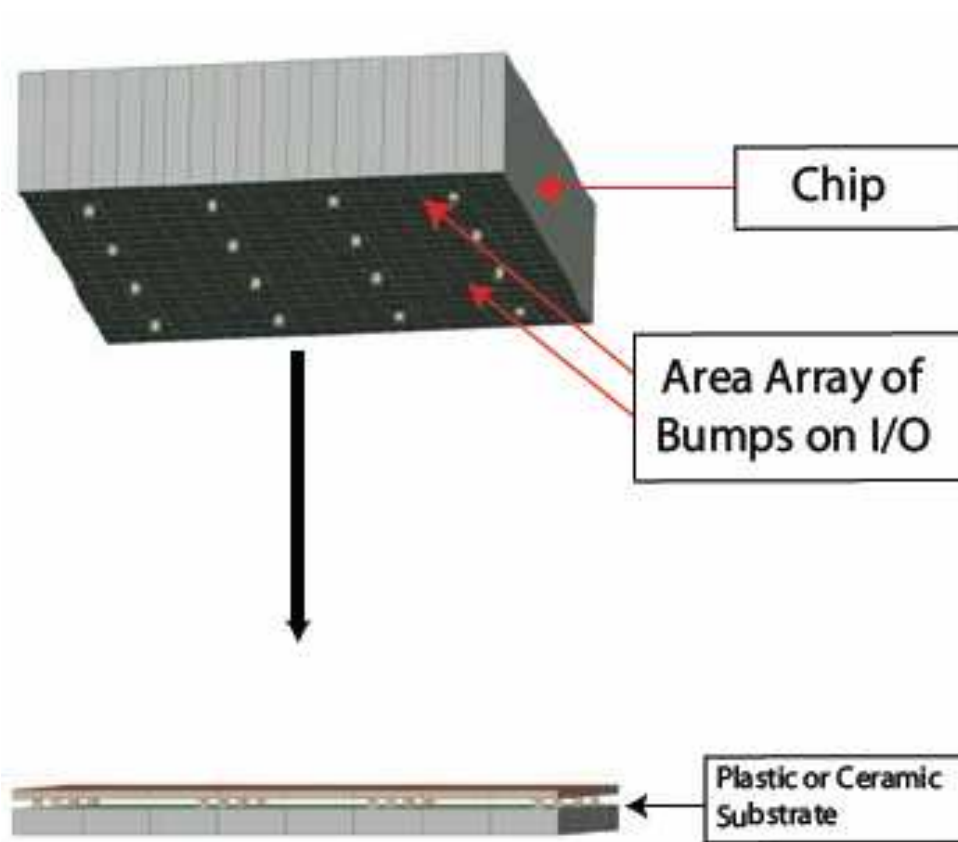
Thermoreflectance dans l'Infra Rouge



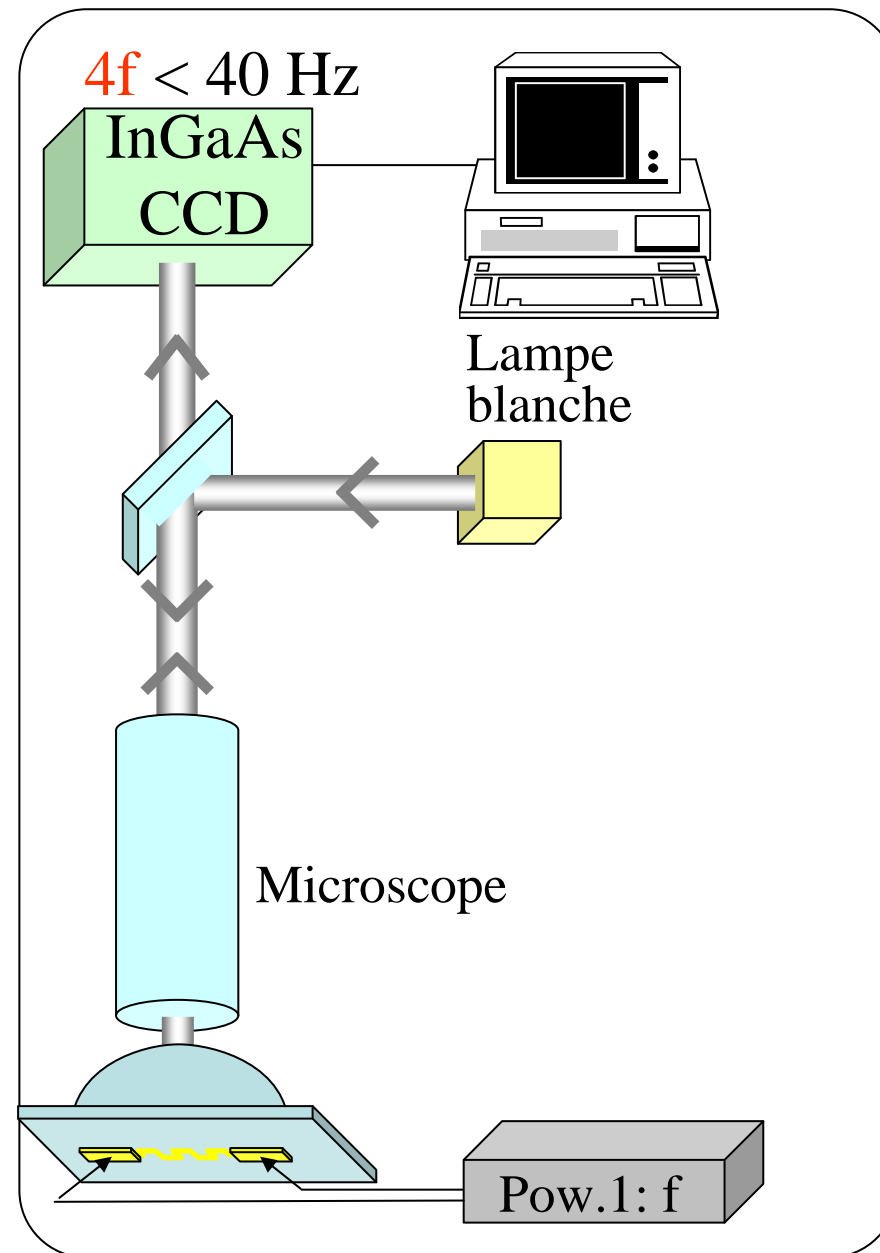
Infrarouge proche

Configurations « flip chip »

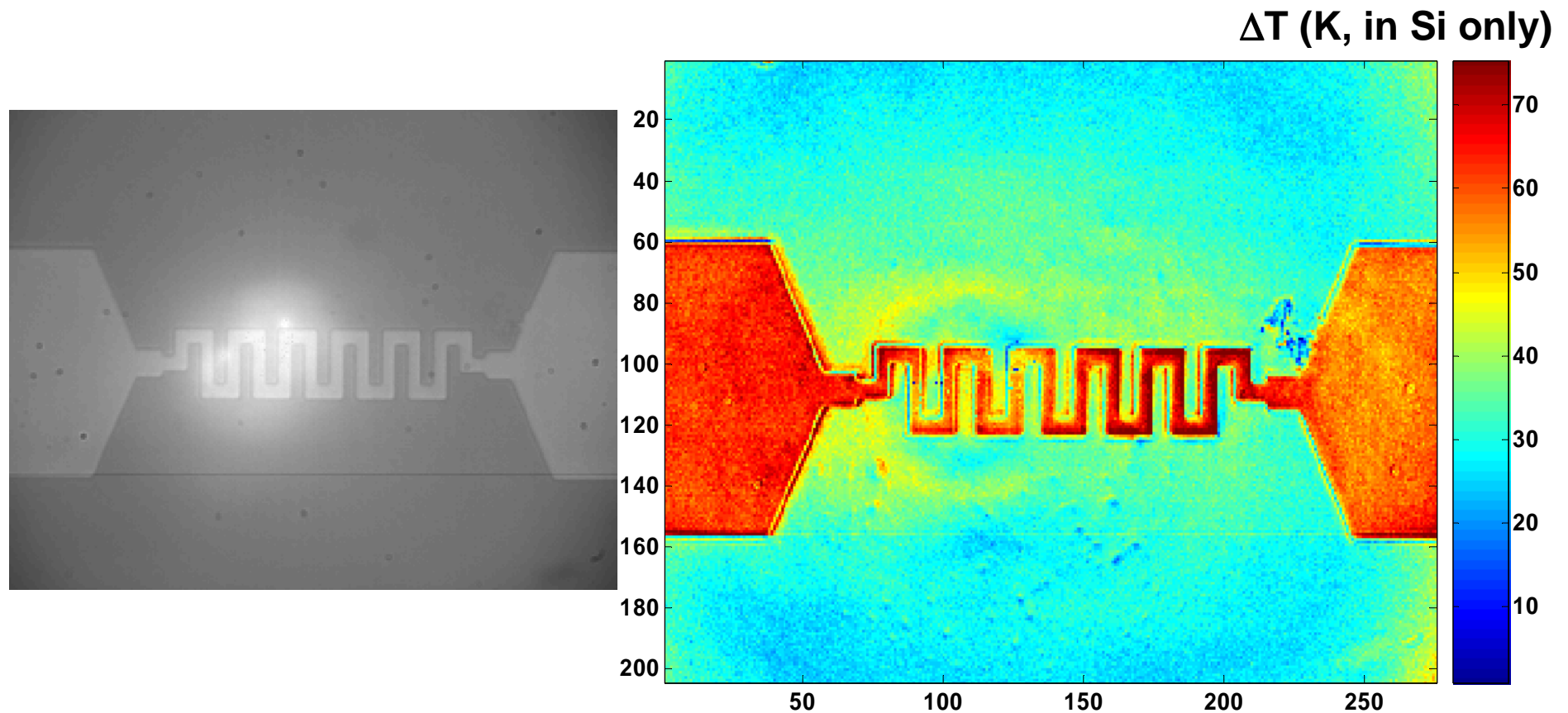
Substrat retourné → face active en contact thermique avec le support



Thermoreflectance avec une caméra InGaAs



Imagerie proche infrarouge en face arrière



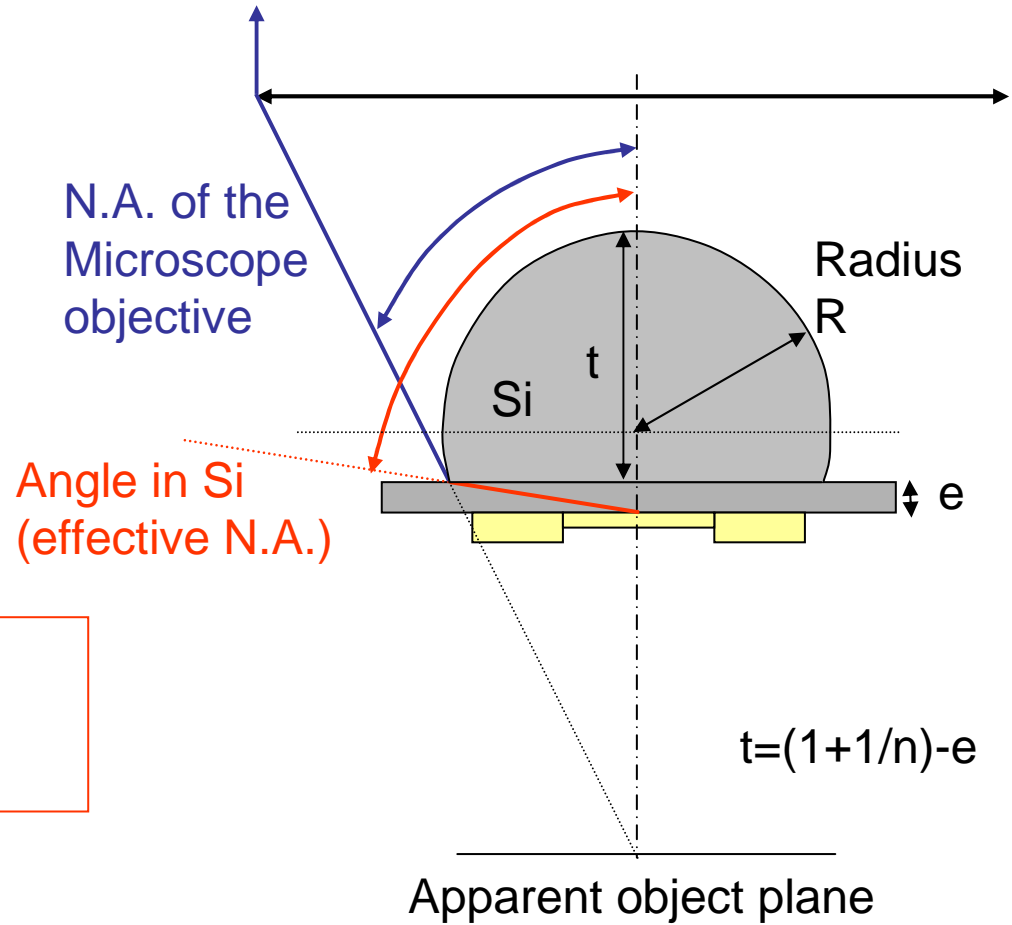
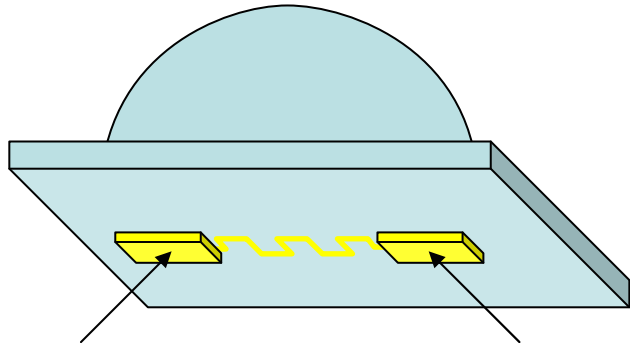
Puissance dissipée : 500 mW

objectif X50, 0.6N.A.

Résolution limitée par la diffraction : 1.7 μm

Lentille à immersion solide: Si

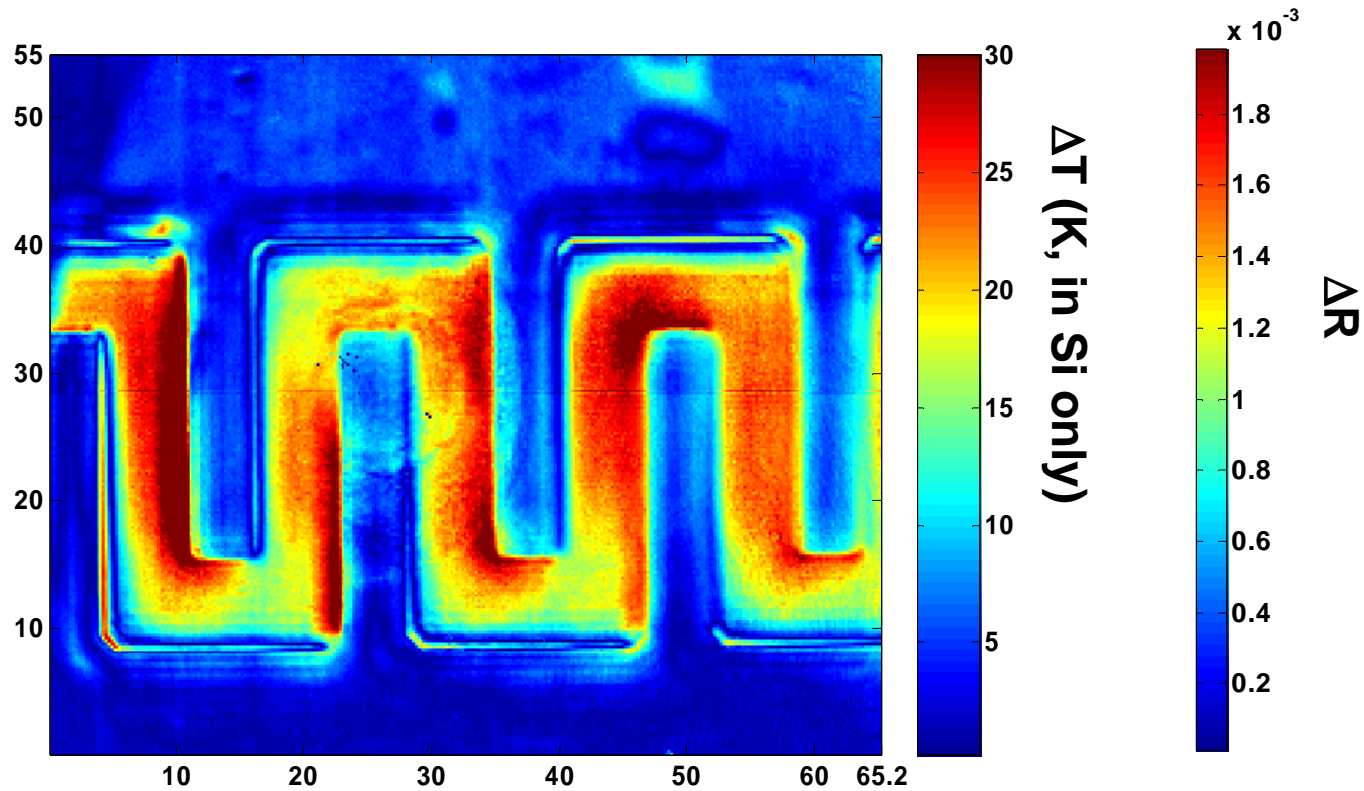
$$n_{\text{Si}} = 3.5$$



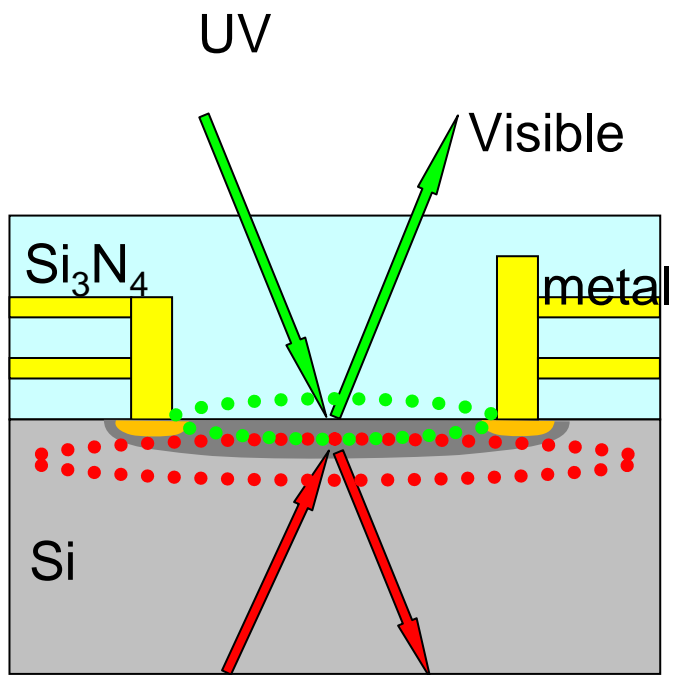
Resolution limit : $1.22 \lambda / 2 \text{ NA}$

in silicon : 245 nm at $\lambda = 1.3 \mu\text{m}$

Thermoreflectance proche infrarouge avec Lentille à Immersion



Résolution moyenne 440 nm
Ouverture numérique 2.36

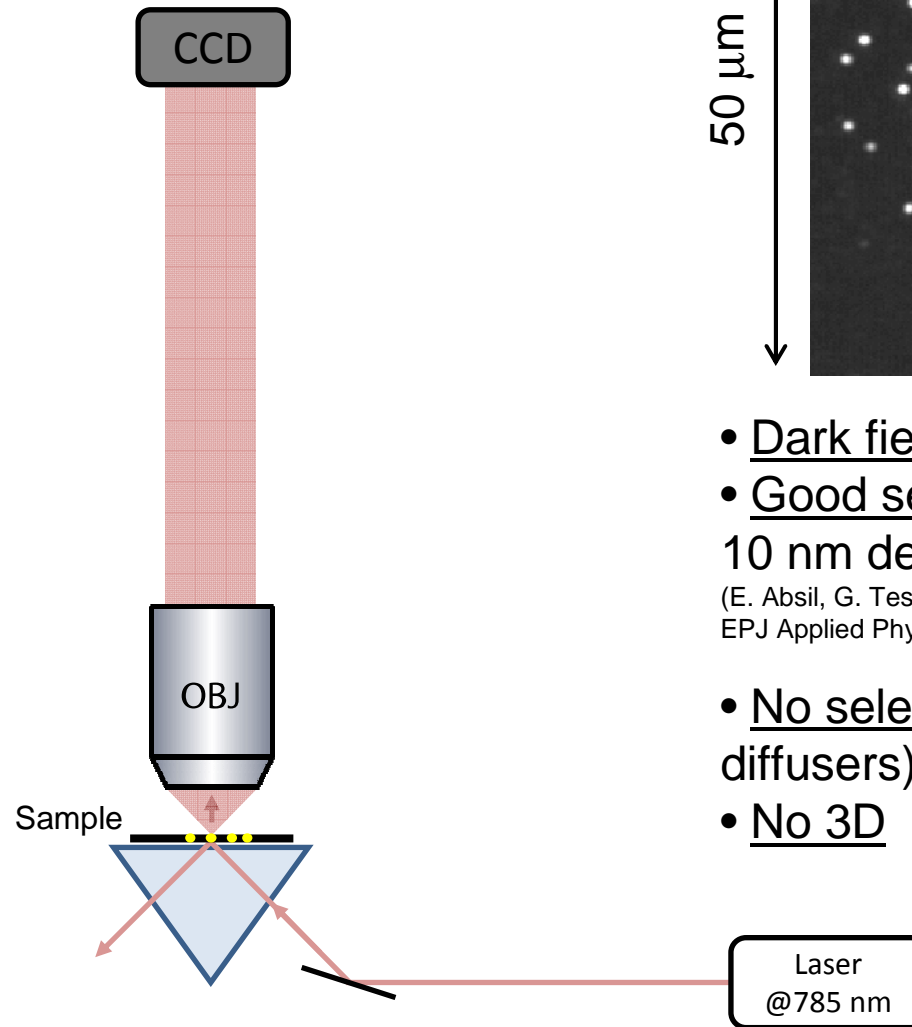


Infrarouge proche

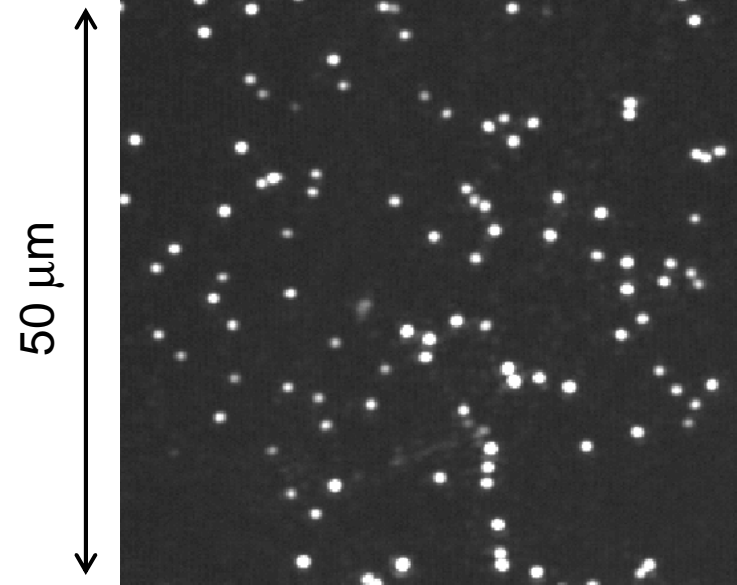
→ Resolution 300 nm – 350 nm

→ Resolution 1.7 μm sans lentille Si
440 nm avec lentille Si

Direct detection of nanoparticles

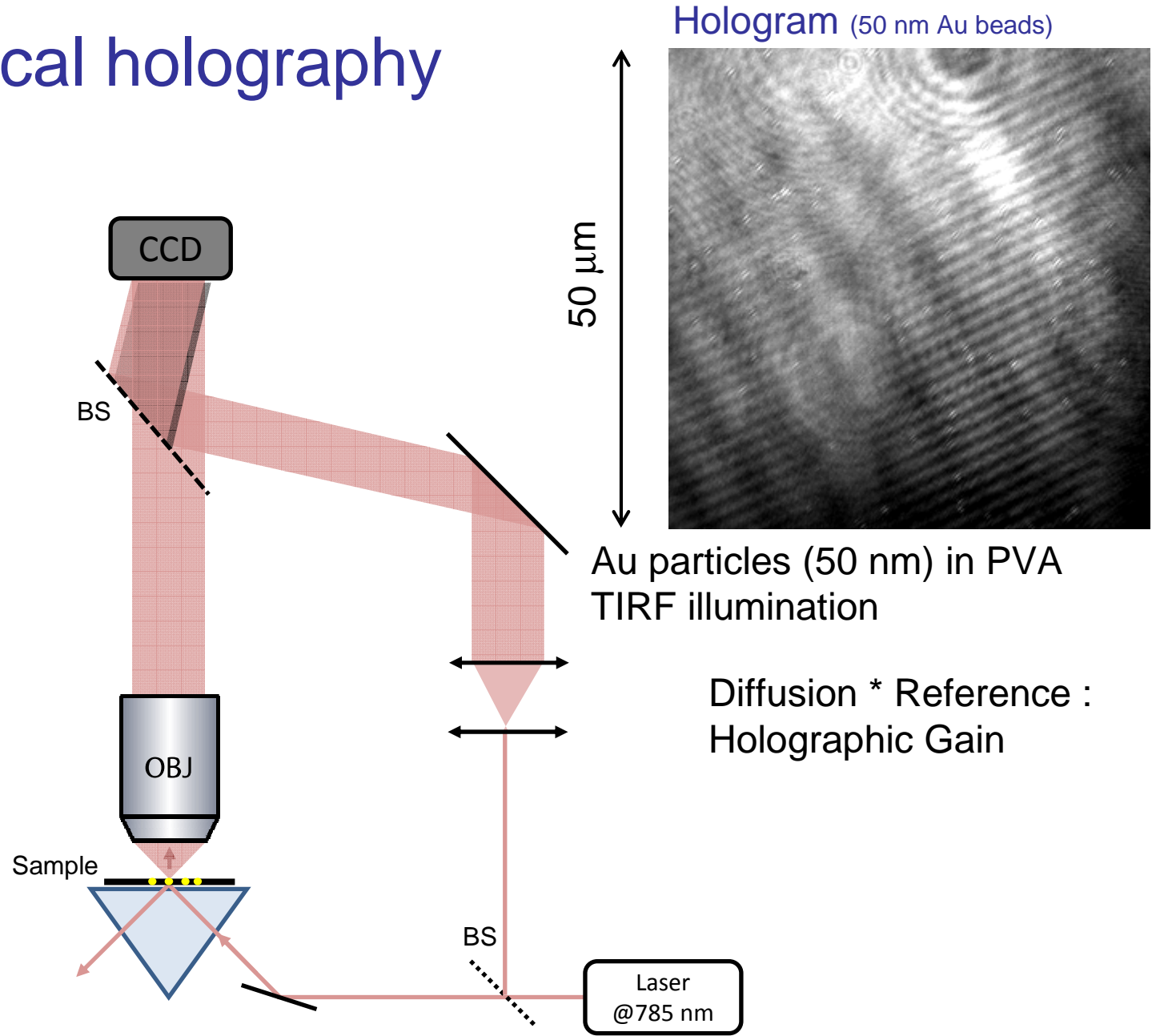


50 nm Au beads
in Poly Vinyl Alcohol

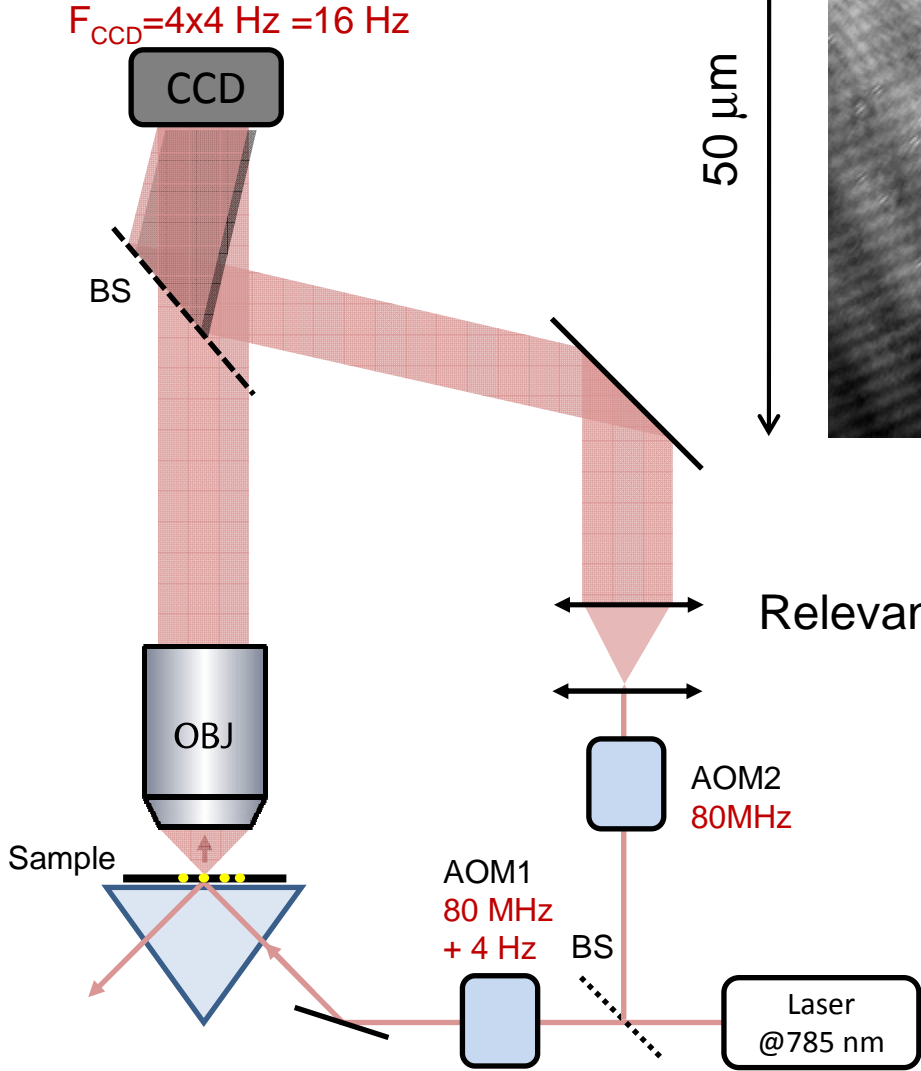


- Dark field
- Good sensitivity :
10 nm demonstrated
(E. Absil, G. Tessier, D. Fournier, M. Atlan, M. Gross, EPJ Applied Physics)
- No selectivity (dust or other diffusers)
- No 3D

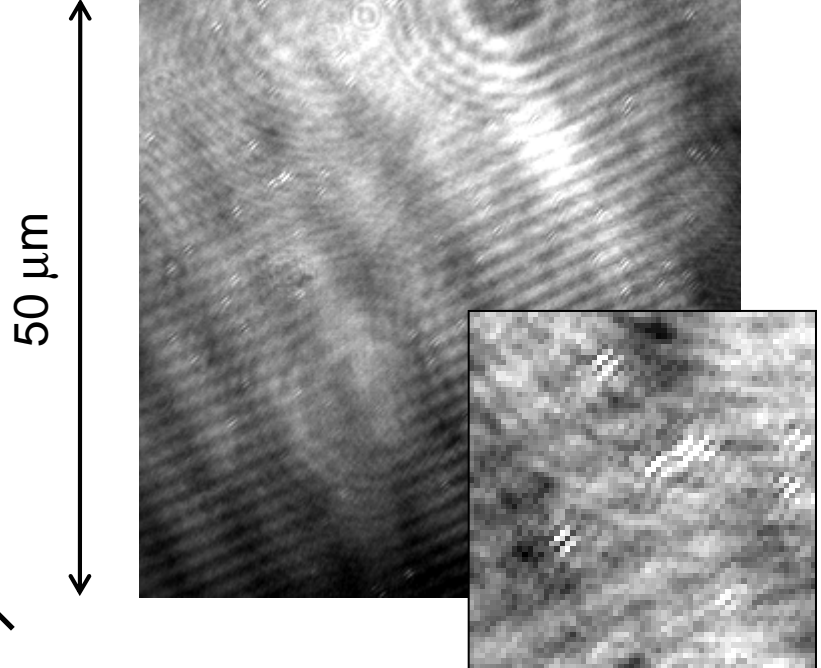
Numerical holography



Heterodyne Numerical holography

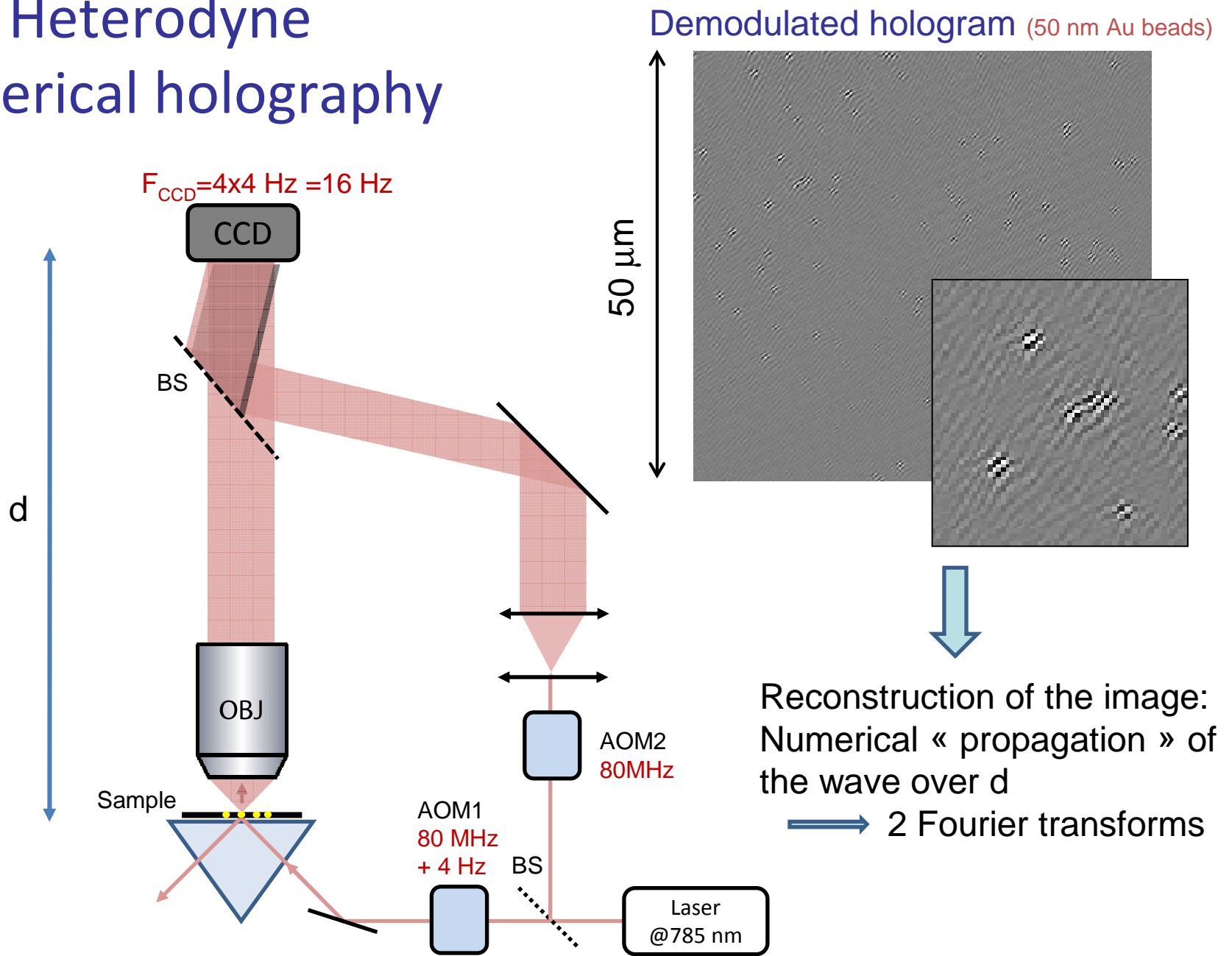


Heterodyne Hologram (50 nm Au beads)



Relevant fringes modulated at 4Hz

Heterodyne Numerical holography



Numerical propagation from the detector to a chosen plane

Recorded Hologram : $H(x, y, 0)$

Hologram in the k -space of wave vectors : $\tilde{H}(k_x, k_y, 0) = \text{FFT}[H(x, y, 0)]$

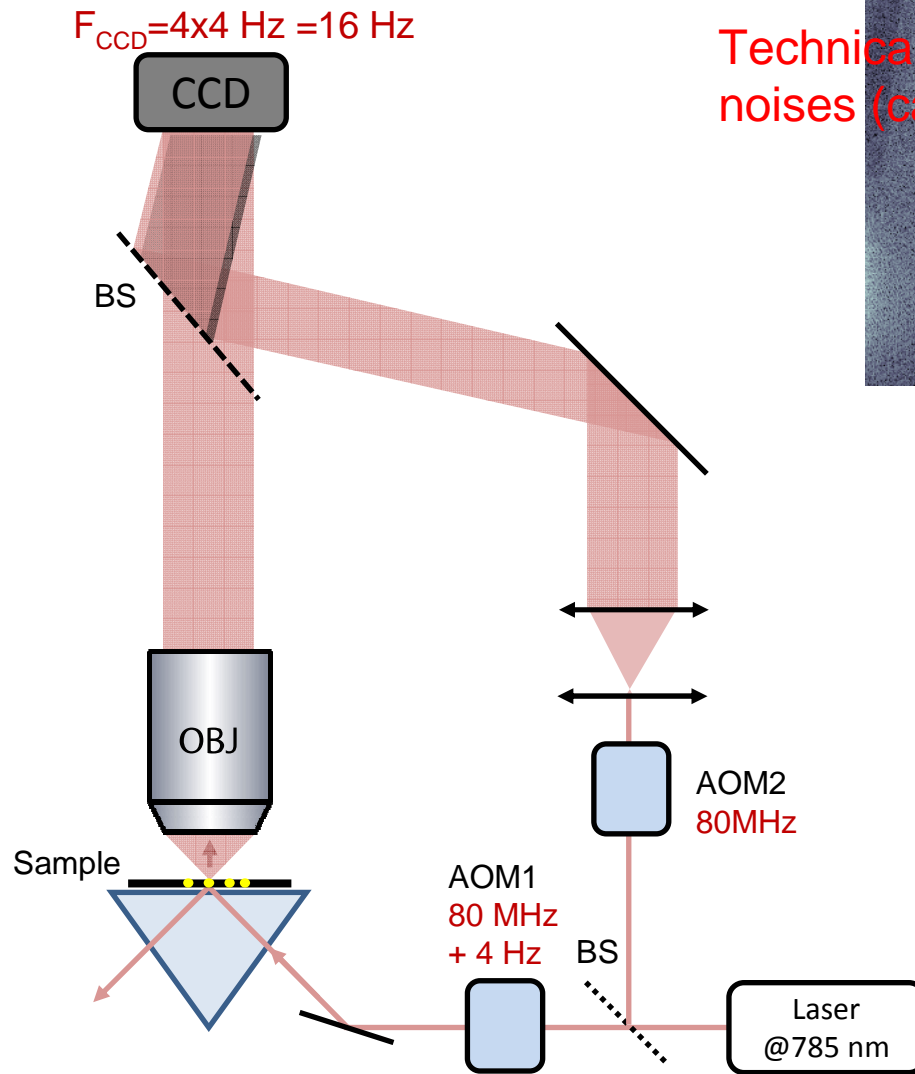
Propagation over distance z : $\tilde{K}(k_x, k_y, z) = e^{jz(k_x^2 + k_y^2)/k}$

$$\tilde{H}(k_x, k_y, z) = \tilde{K}(k_x, k_y, z)\tilde{H}(k_x, k_y, 0)$$

Reconstructed hologram in the chosen plane ($z=d$): $H(x, y, z) = \text{FFT}^{-1}[\tilde{H}(k_x, k_y, z)]$

⇒ 2 Fourier transforms

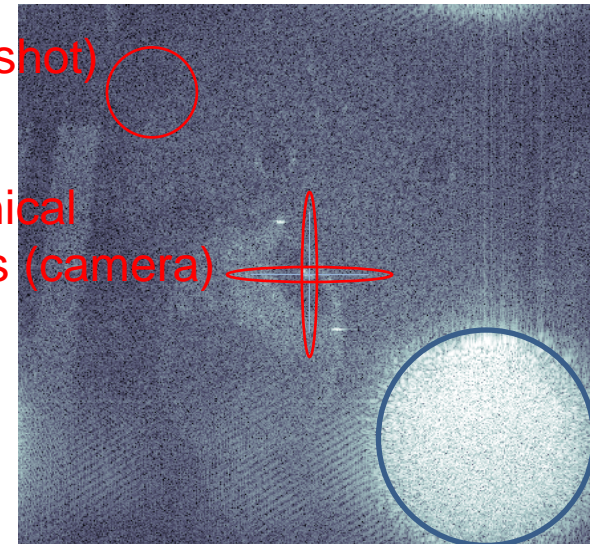
Heterodyne Numerical holography



2D Fourier transform of the hologram

Photon (shot) noise

Technical noises (camera)



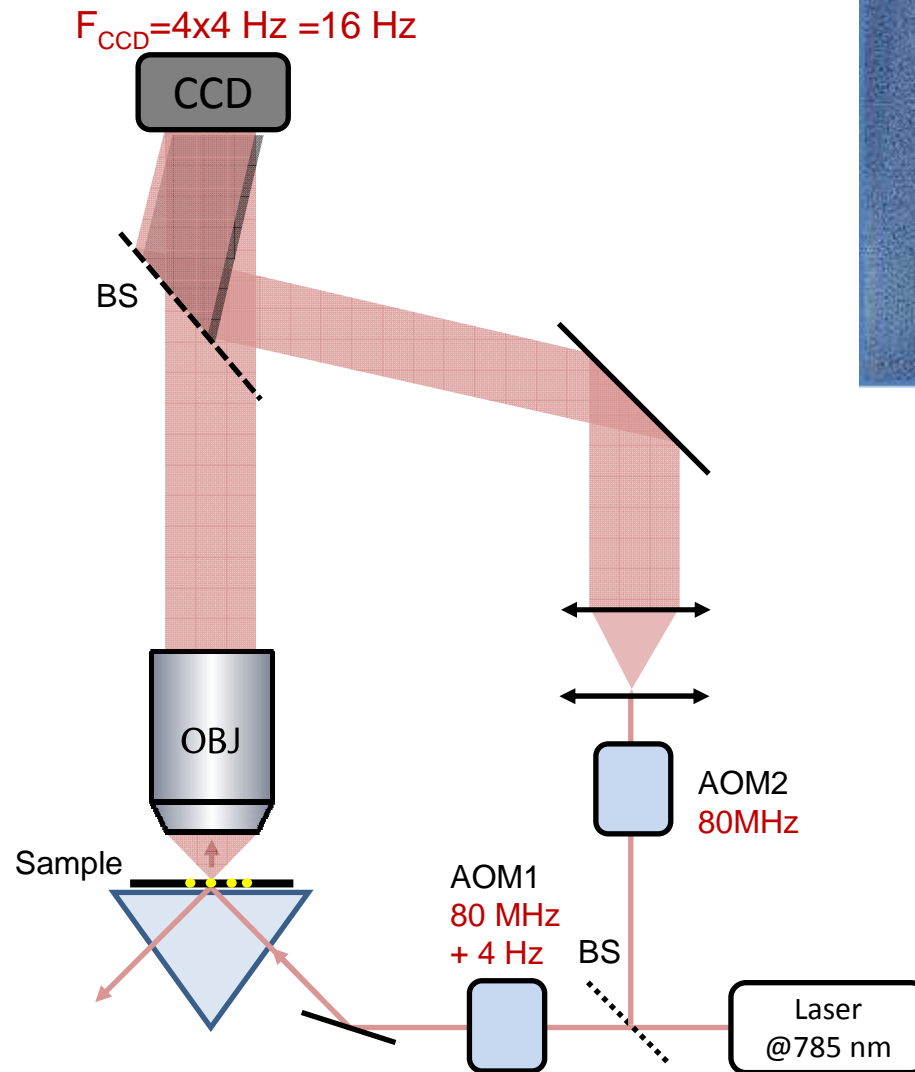
Relevant signal:
Exit pupil of the objective

1st Fourier transform :

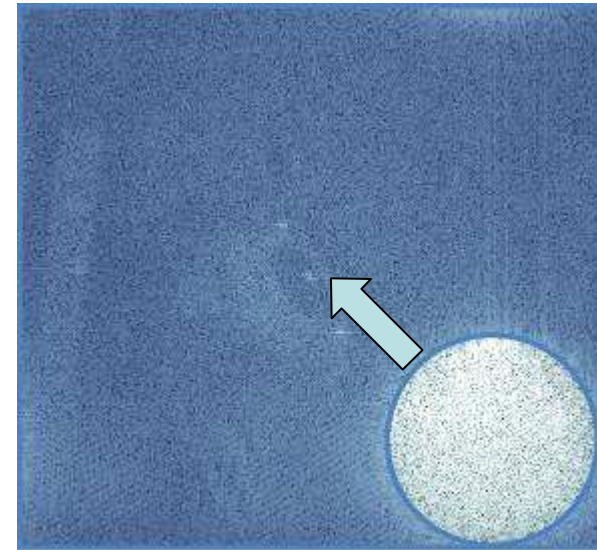


Wave vectors, k

Heterodyne Numerical holography



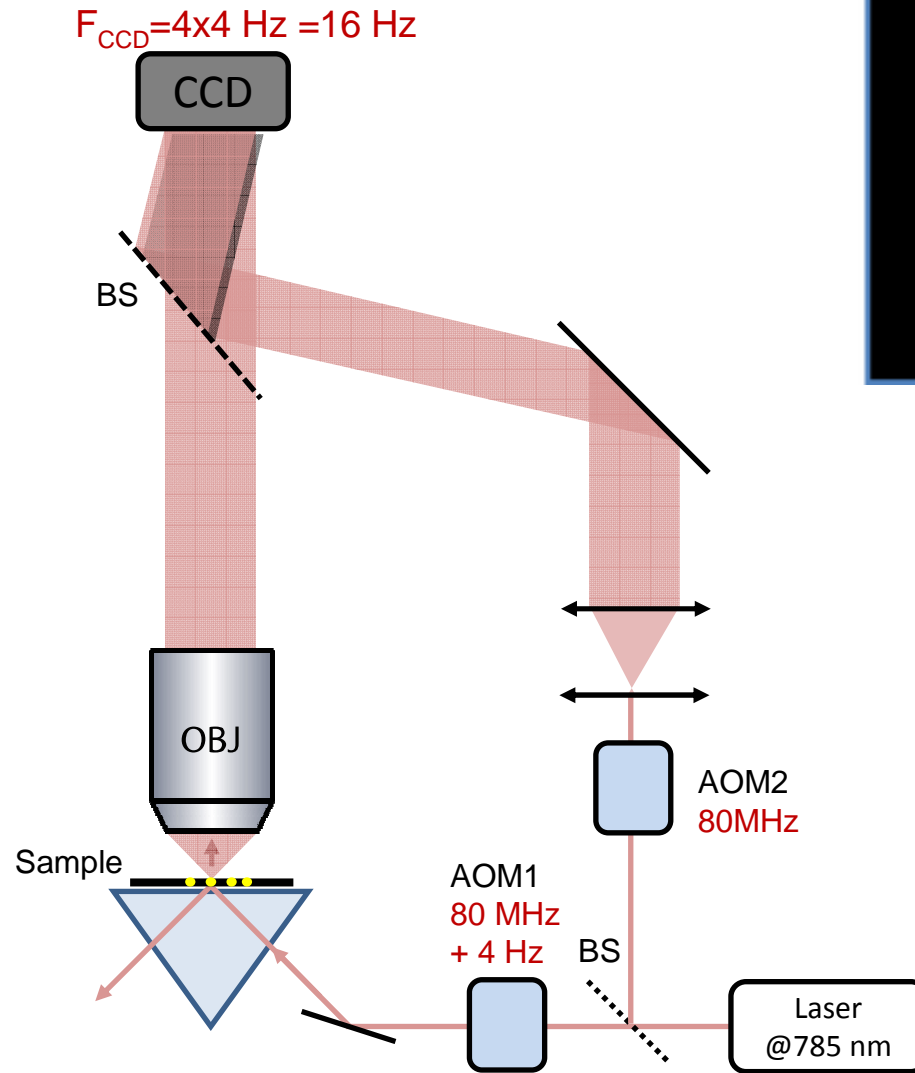
2D Fourier transform of the hologram



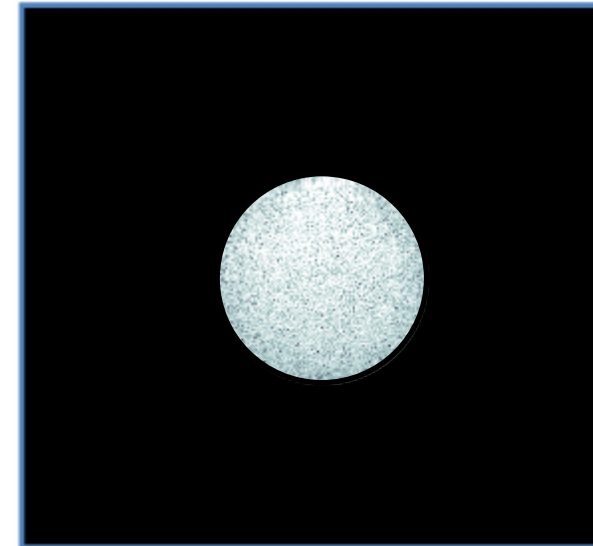
Relevant signal:
Exit pupil of the objective

Filtering in the wave
vectors space

Heterodyne Numerical holography



2D Fourier transform of the hologram



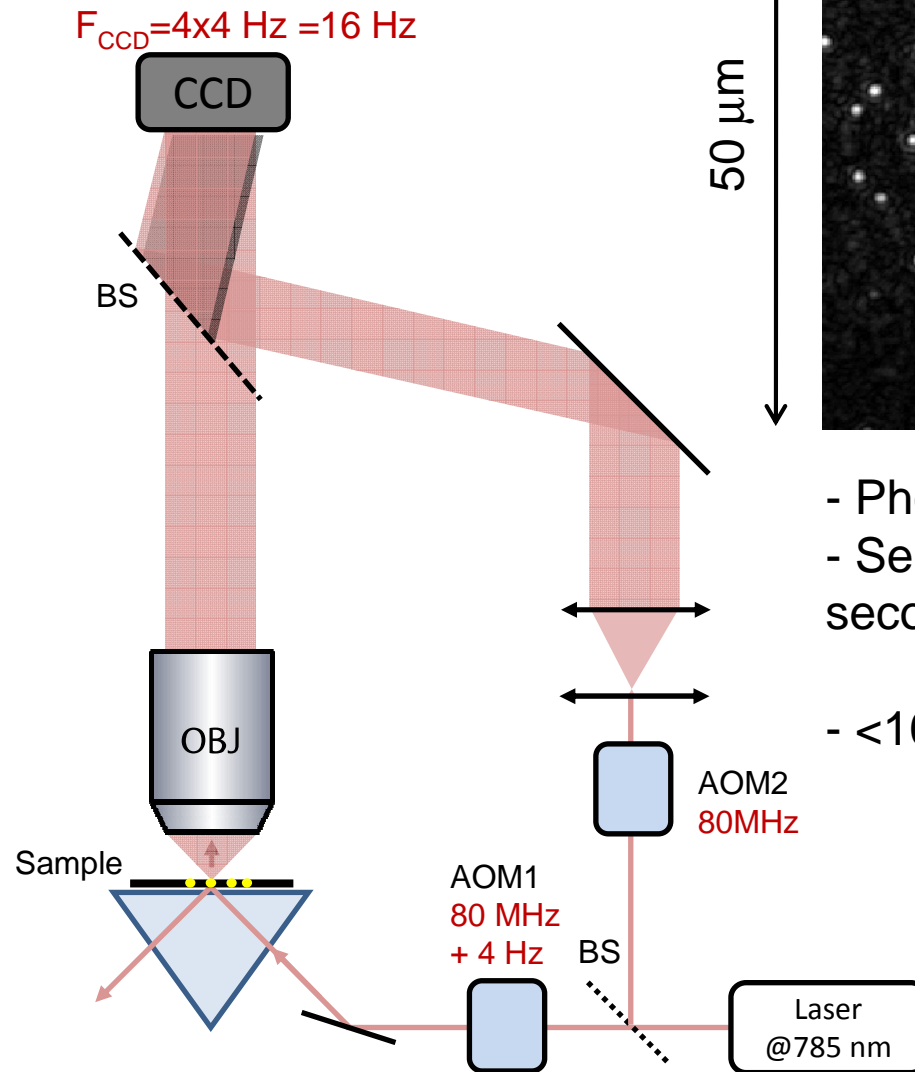
Relevant signal:
Exit pupil of the objective

Filtering in the wave
vectors space

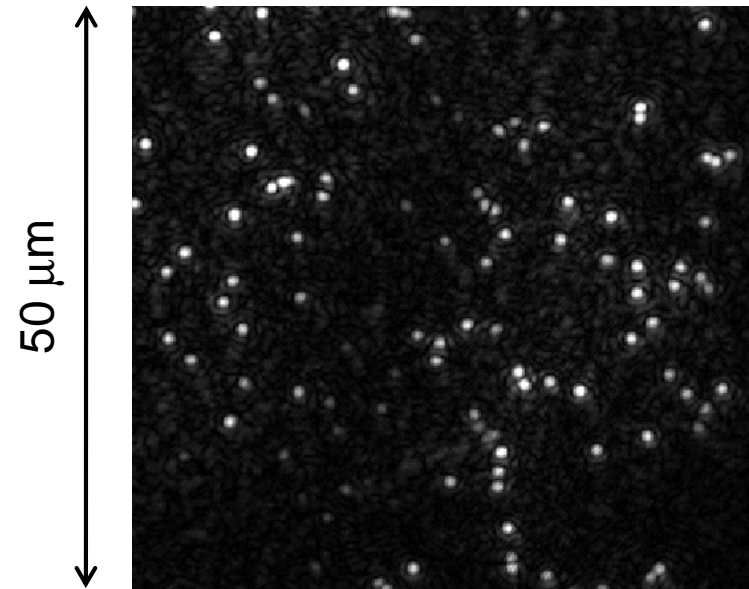


2nd Fourier transform

Heterodyne Numerical holography



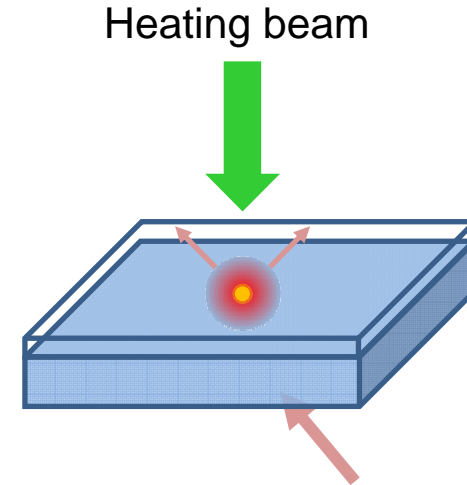
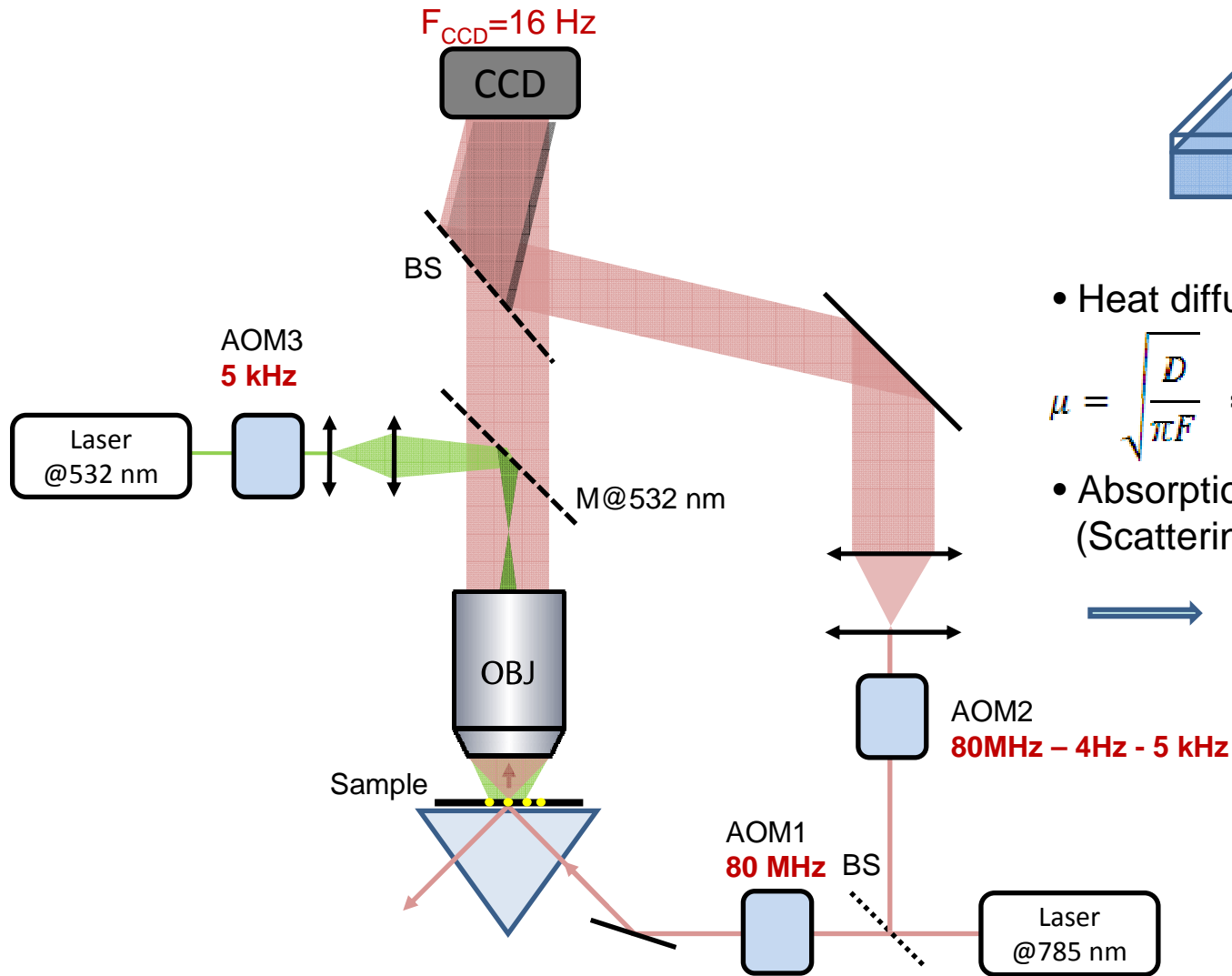
Reconstructed image (50 nm Au beads)



- Photon-noise limited detection¹
- Sensitivity¹ : 1 photon per second per pixel
- <10 nm

¹ M. Atlan , M. Gross, E. Absil, Opt. Lett. 32, 1456 (2007)
M. Gross, M. Atlan, Opt. Lett. 32, 909 (2007)

Photothermal Numerical holography



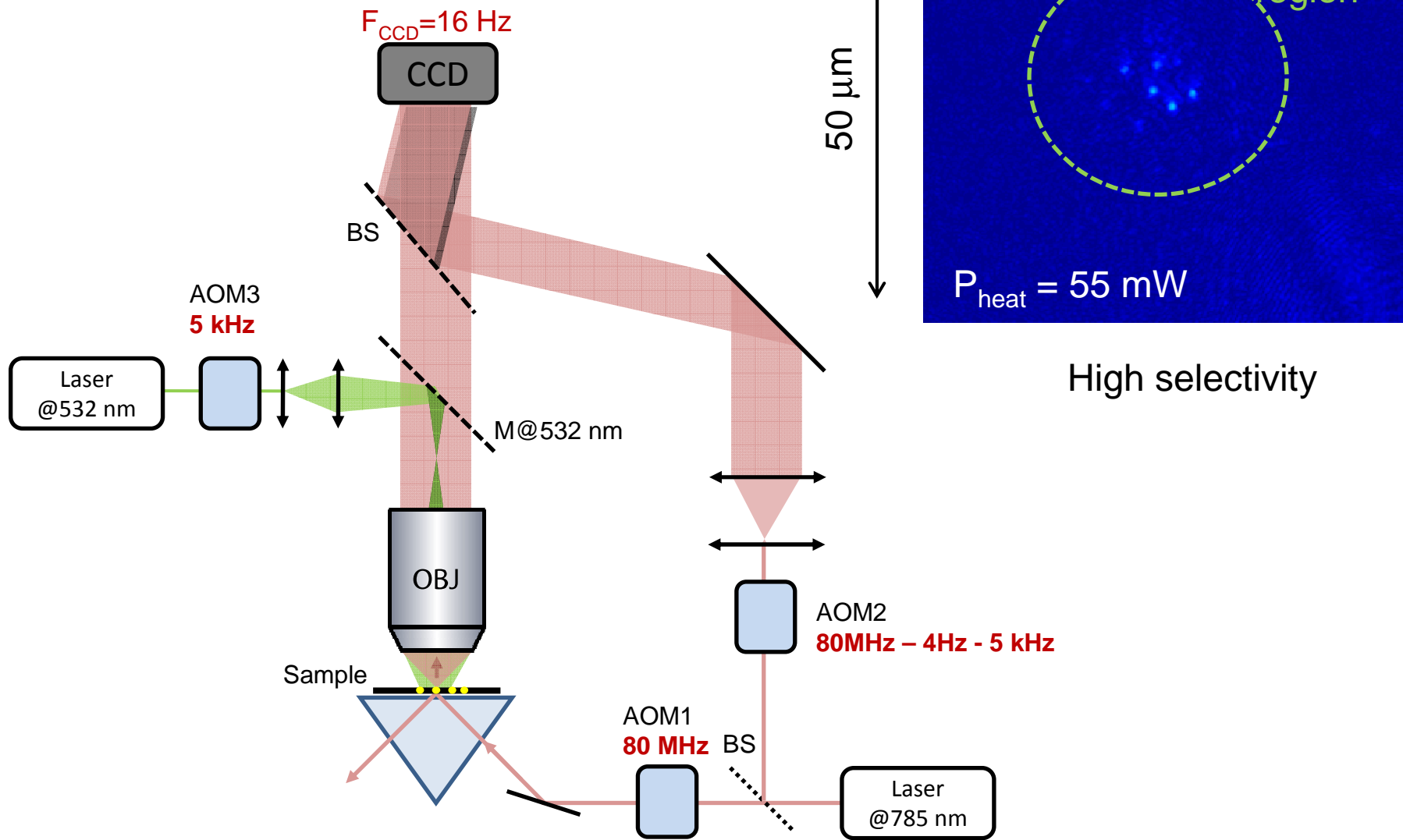
- Heat diffusion around the sphere :

$$\mu = \sqrt{\frac{D}{\pi F}} \approx 7 \text{ } \mu\text{m at } 5 \text{ kHz} \gg 50 \text{ nm} !$$

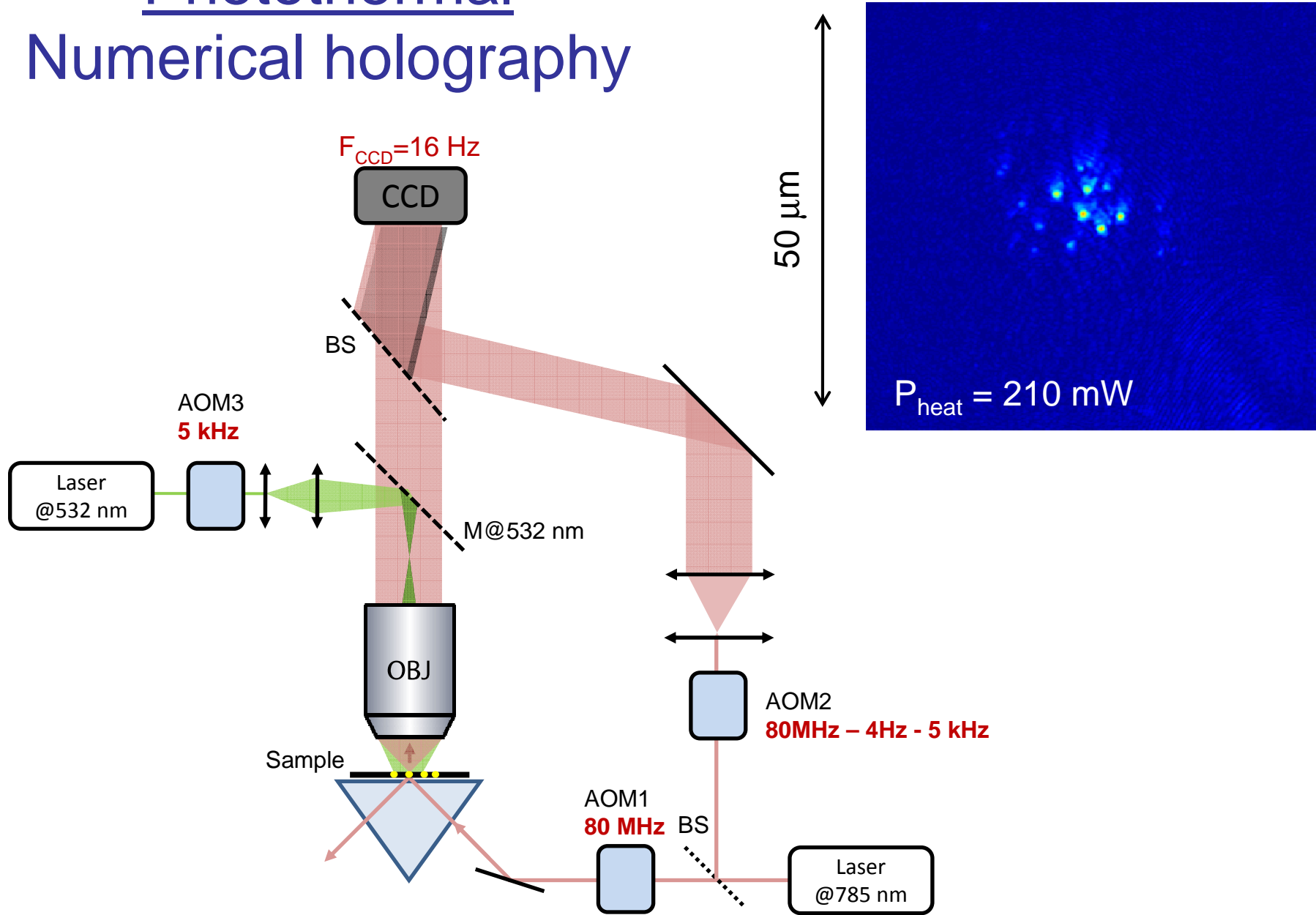
- Absorption decreases as d^3
(Scattering decreases as d^6)

➡ Smaller particles ?

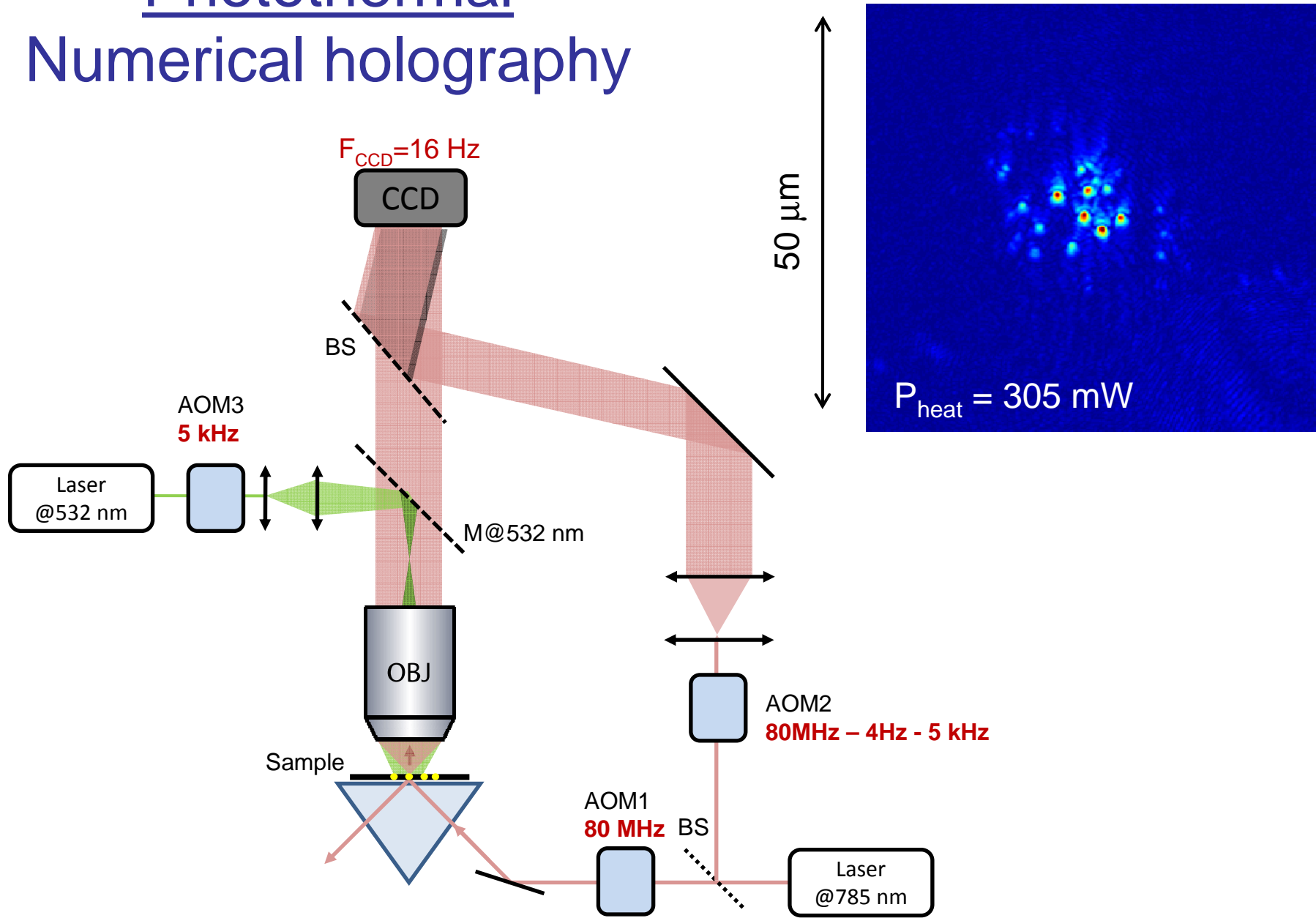
Photothermal Numerical holography



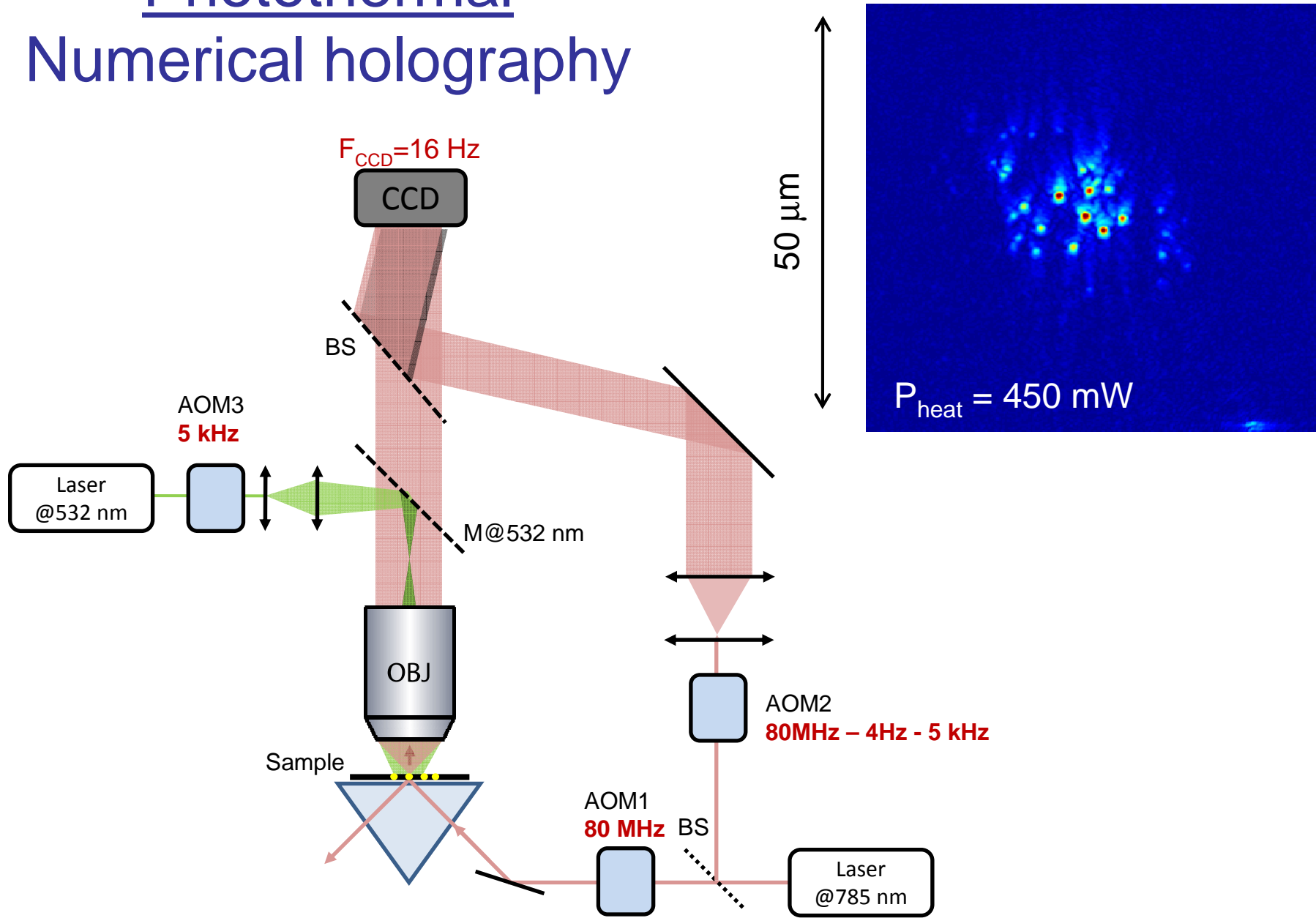
Photothermal Numerical holography



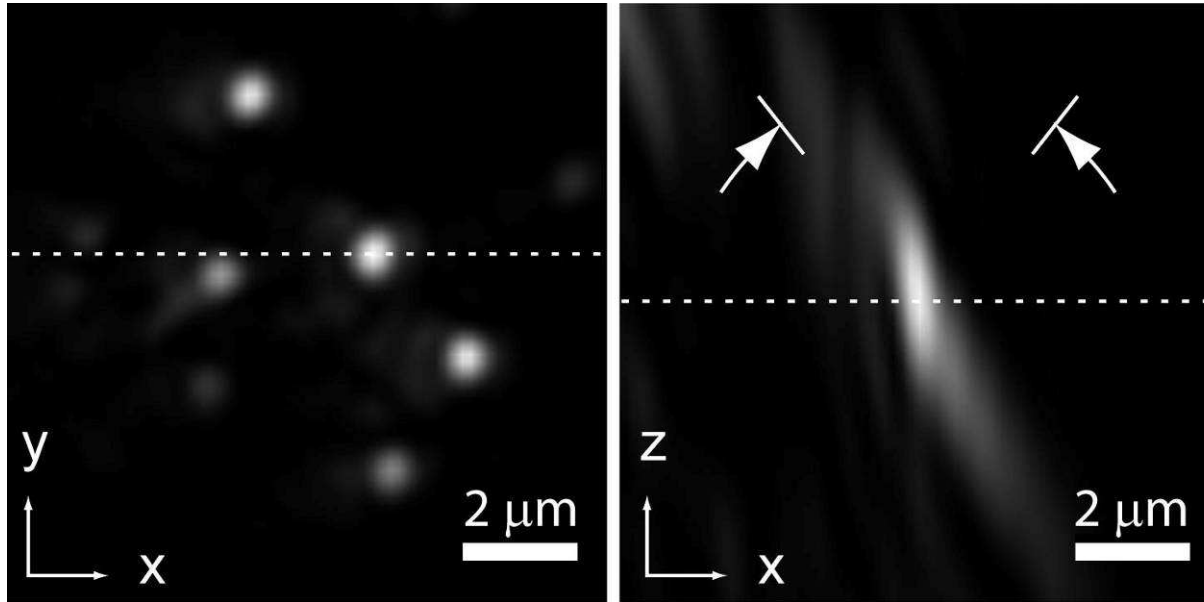
Photothermal Numerical holography



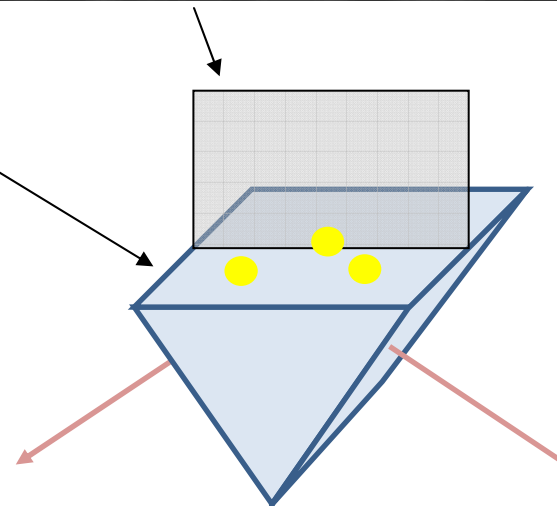
Photothermal Numerical holography



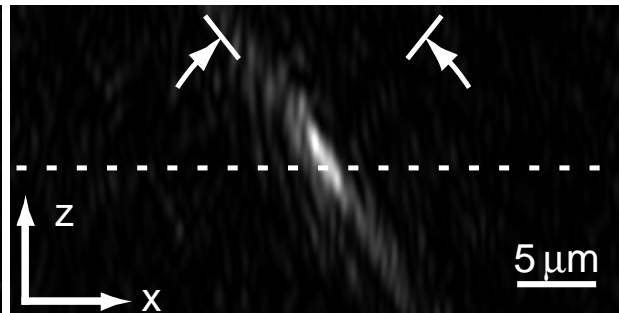
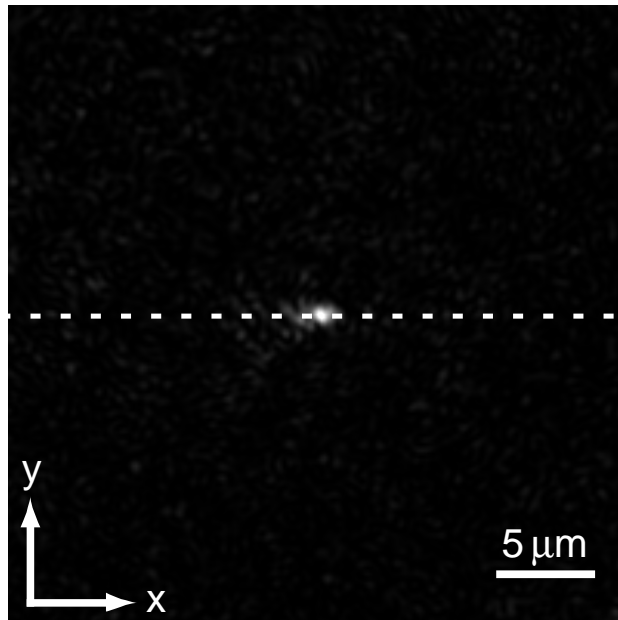
50 nm particles



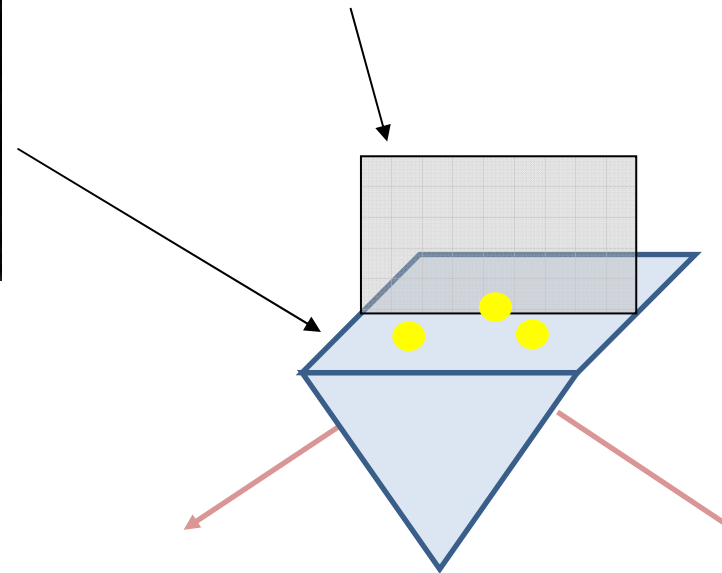
Heating :
5 kHz, 450 mW.



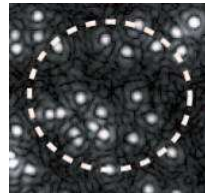
10 nm particles



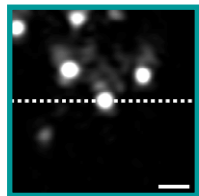
Heating :
5 kHz, 450 mW.



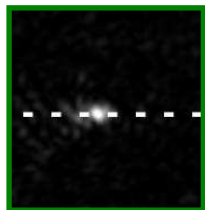
Comparison of the signals



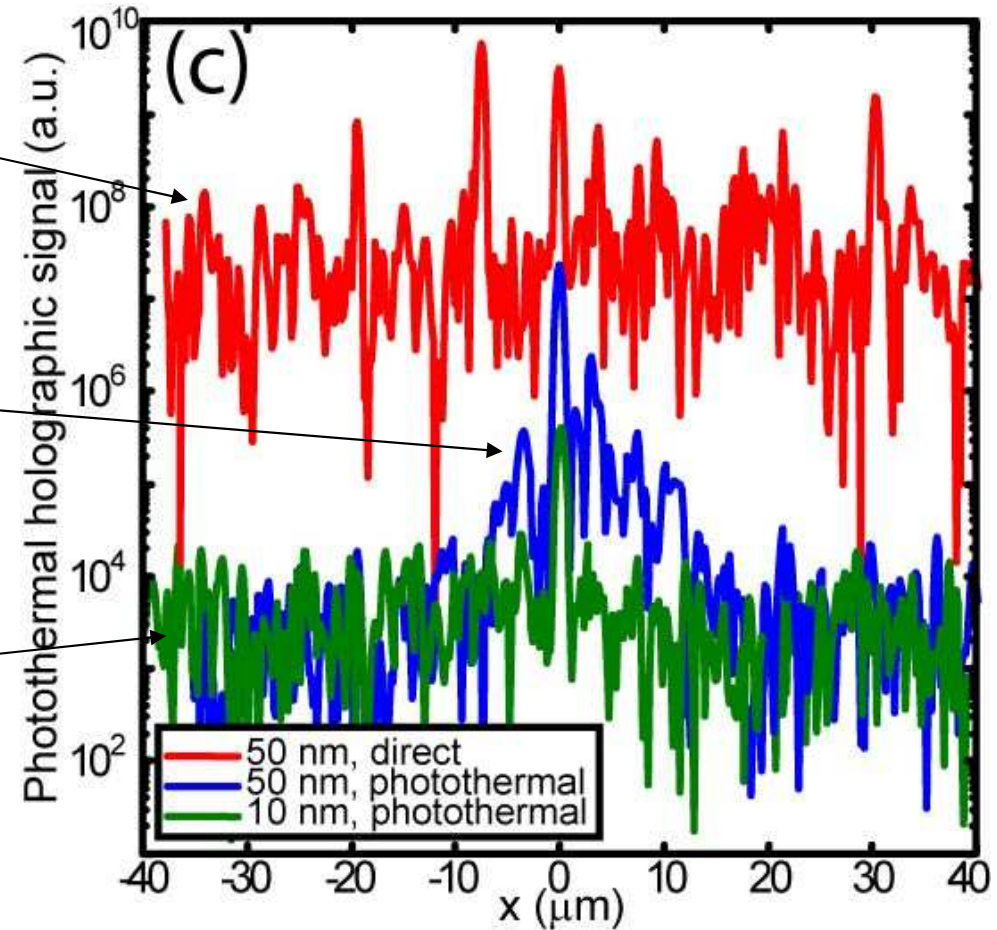
50 nm,
Non photothermal



50 nm,
Photothermal

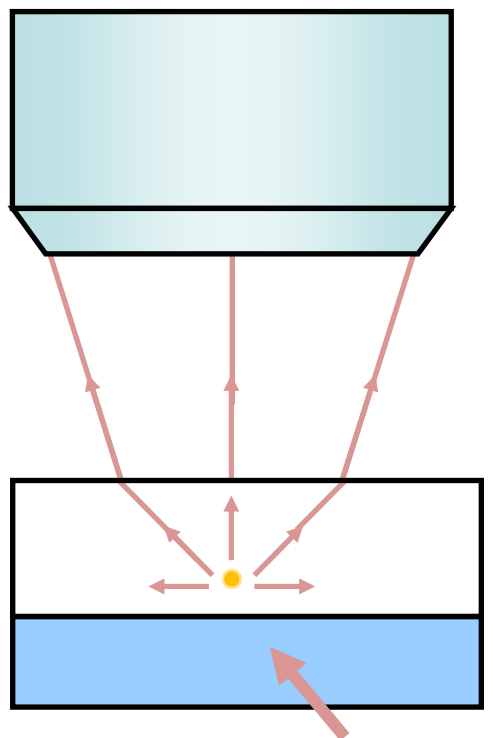


10 nm,
Photothermal

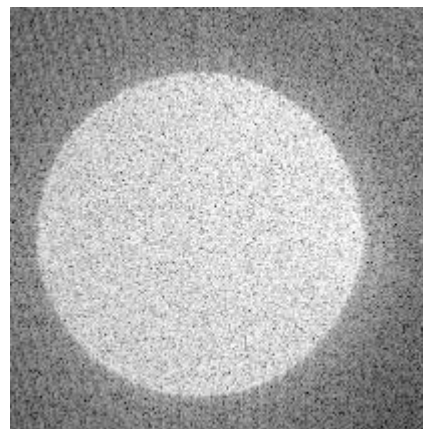


- The signal (scattering) is lower in photothermal mode
- BUT the signal to noise ratio is 1000 times higher for 50 nm beads

Reconstruction at the exit pupil of the objective :
k wave vectors



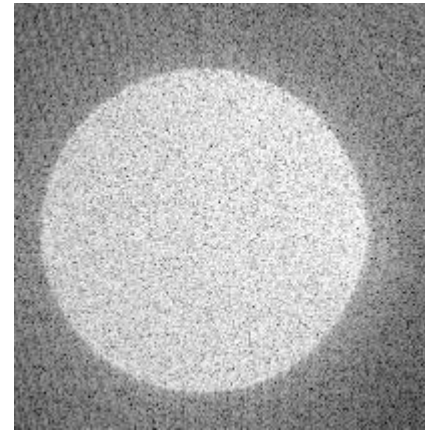
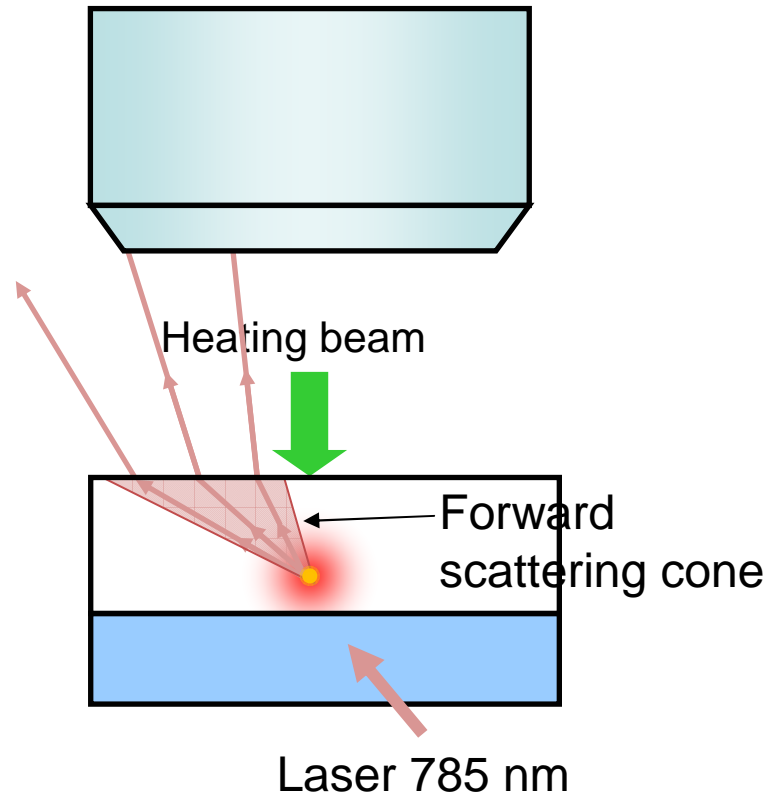
Laser 785 nm



50 nm beads,
non photothermal

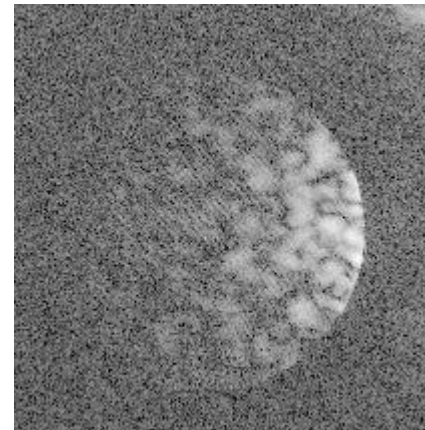
Quasi isotropic
scattering

Reconstruction at the exit pupil of the objective :
 k wave vectors



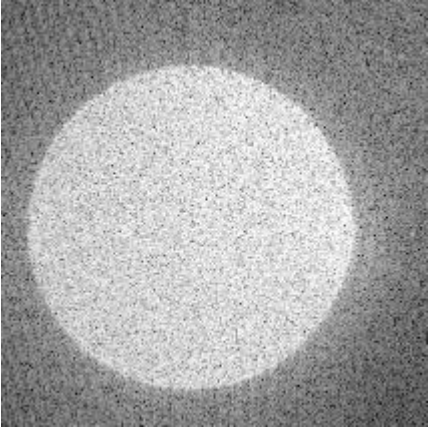
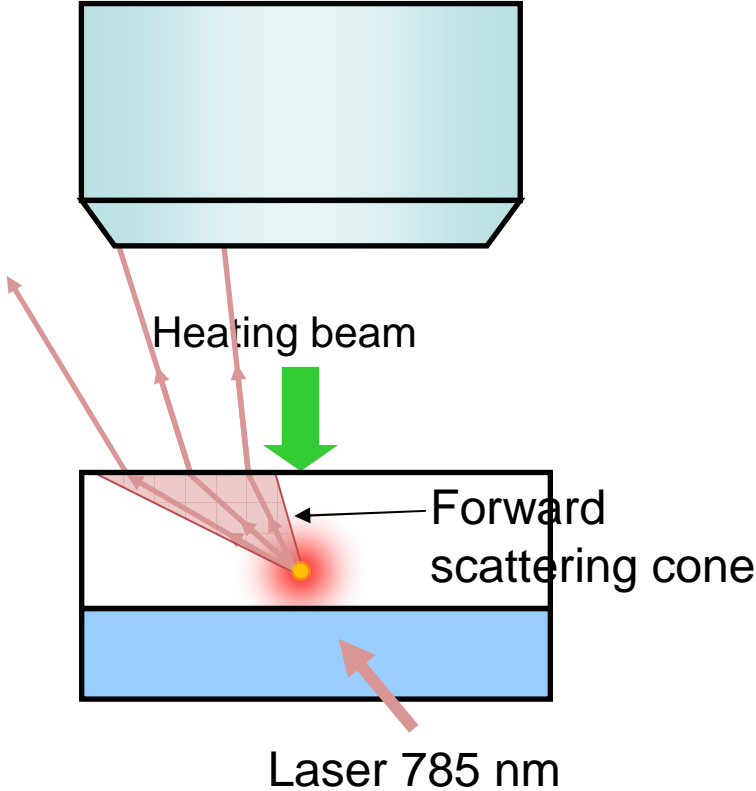
50 nm beads,
non photothermal

Quasi isotropic
scattering

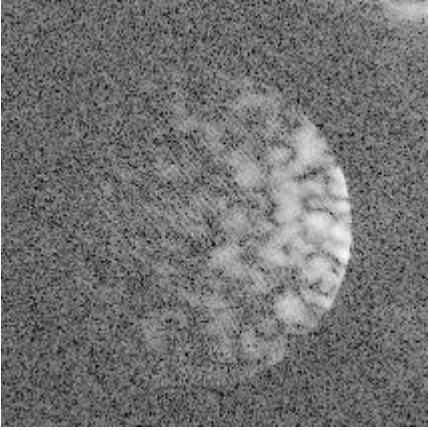


50 nm beads,
photothermal

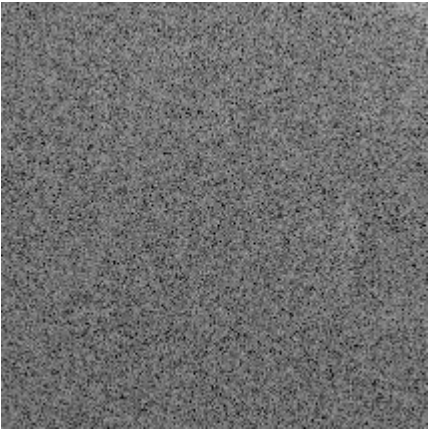
Reconstruction at the exit pupil of the objective : k wave vectors



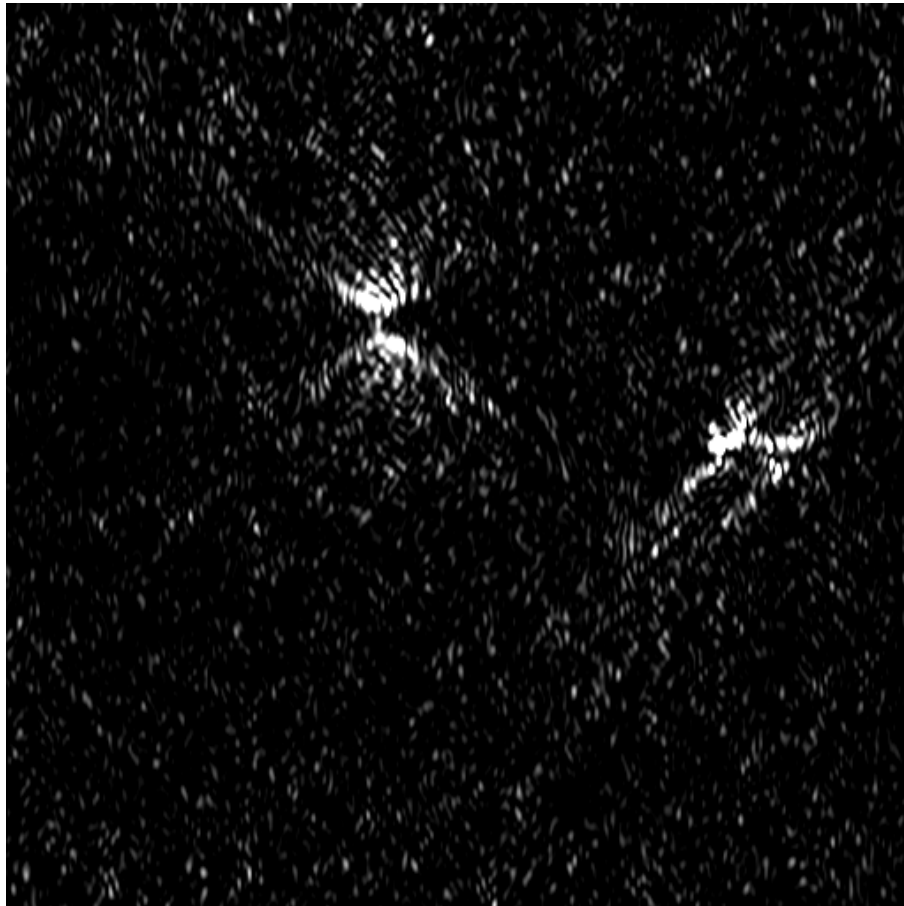
50 nm beads,
non photothermal



50 nm beads,
photothermal



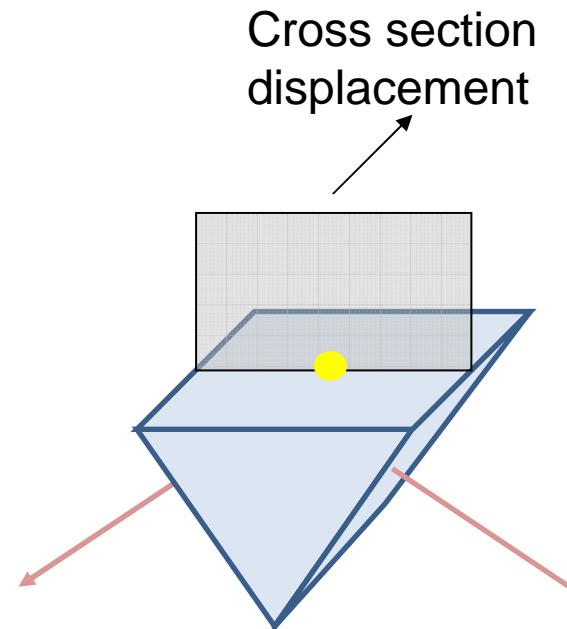
10 nm beads,
photothermal



10 nm beads

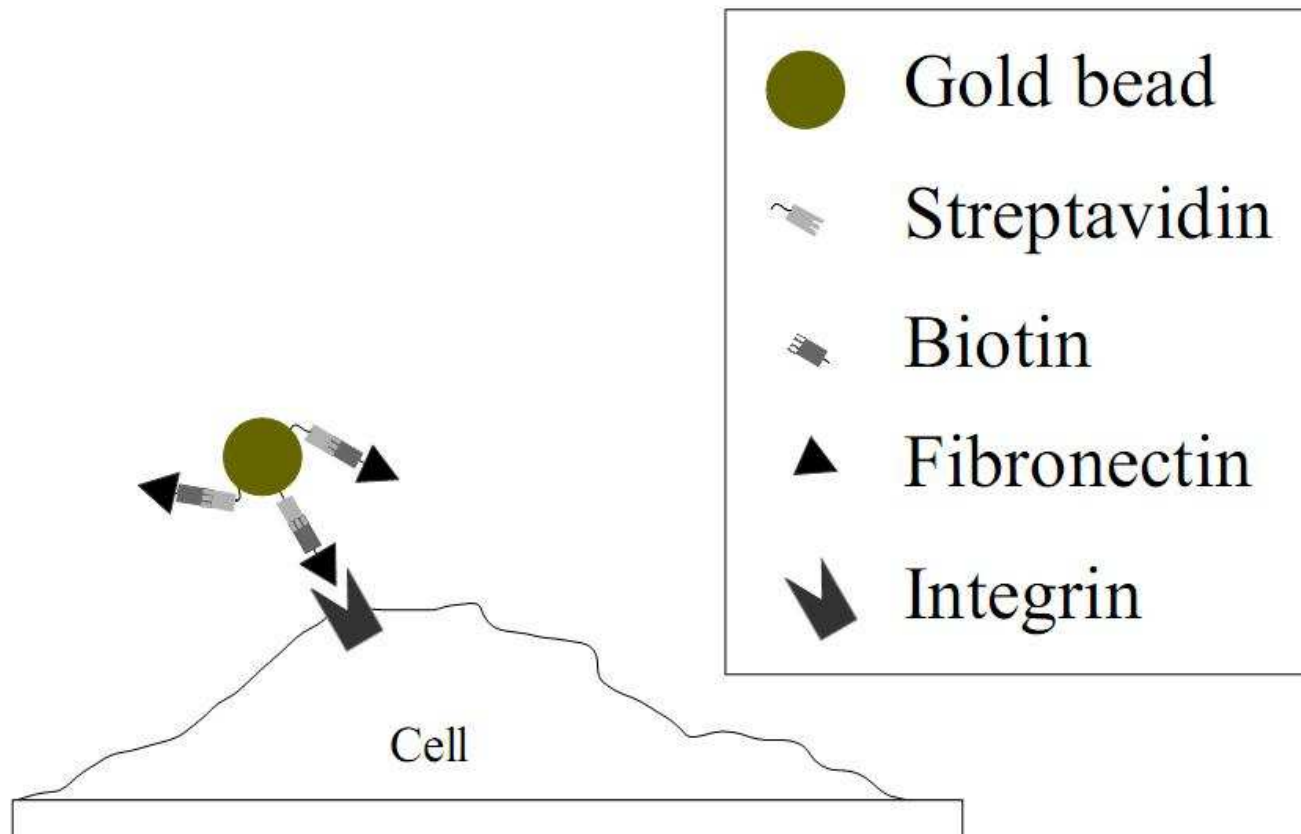
Different scattering from gold beads and dust

Film reconstructed from a single hologram (acquisition < 5s)

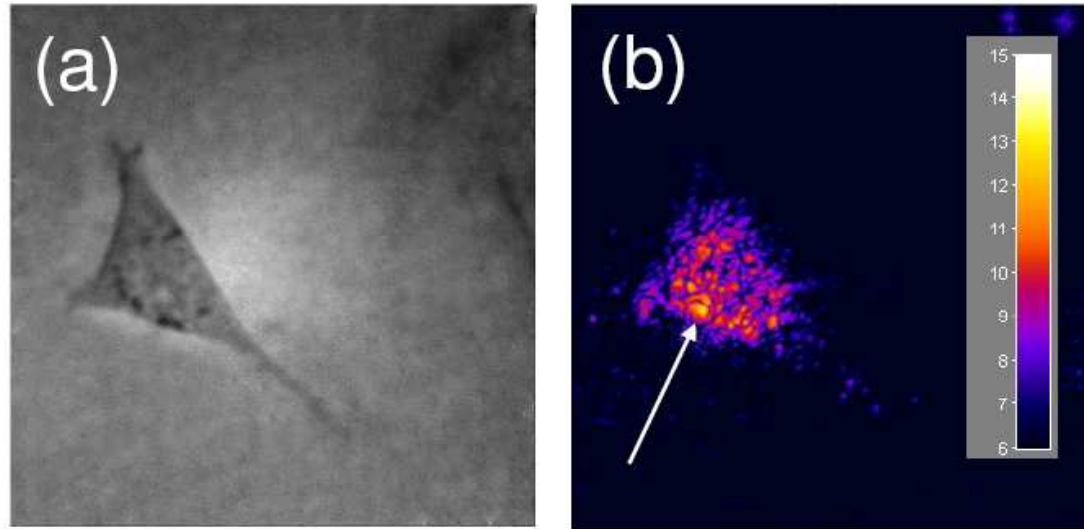


Sample preparation

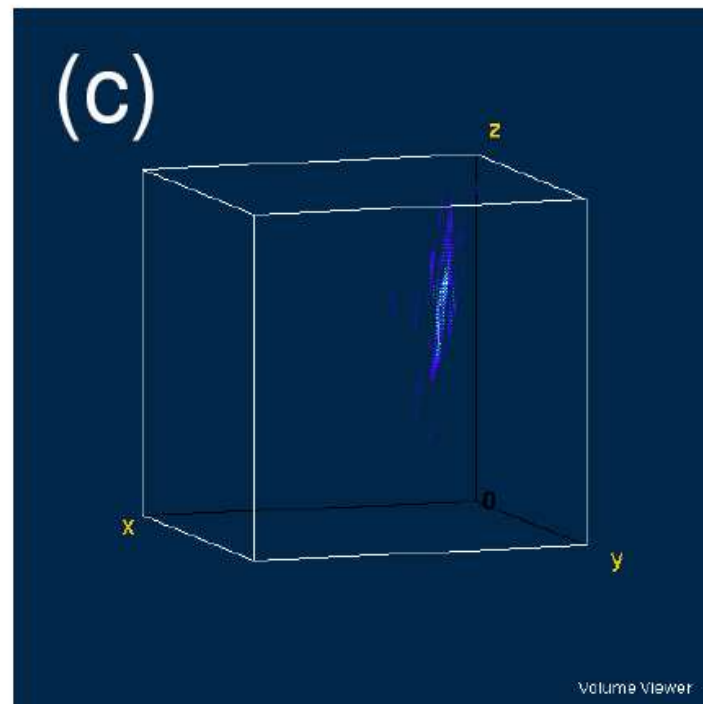
Sample: 3T3 mouse fibroblast + 40 nm gold particles



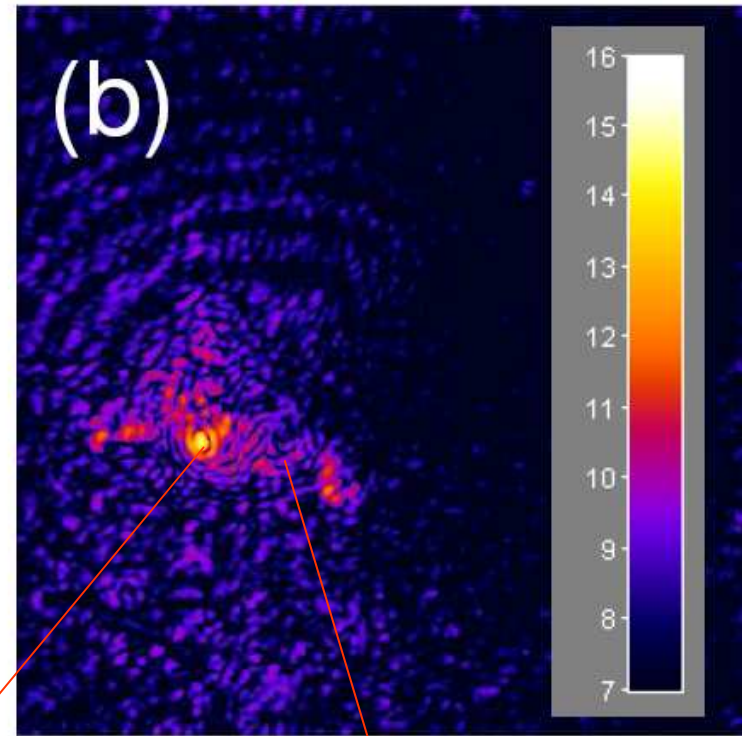
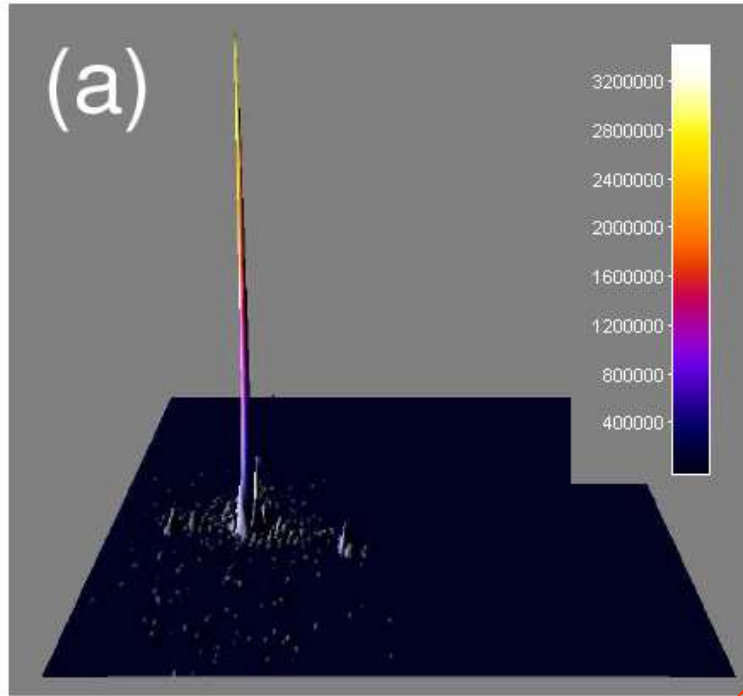
(Philippe Bun, Maité Coppey-Moisan: Département de Biologie Cellulaire, Institut Jacques Monod, Paris.)



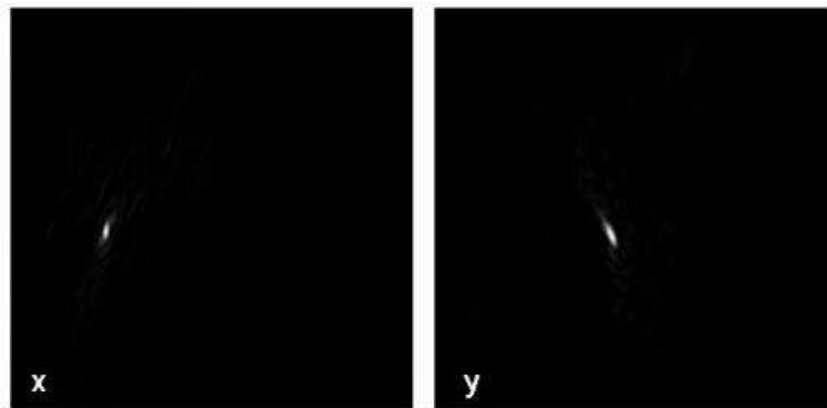
Bille d'or 40 nm
Accumulation 32 images
(env. 2s)



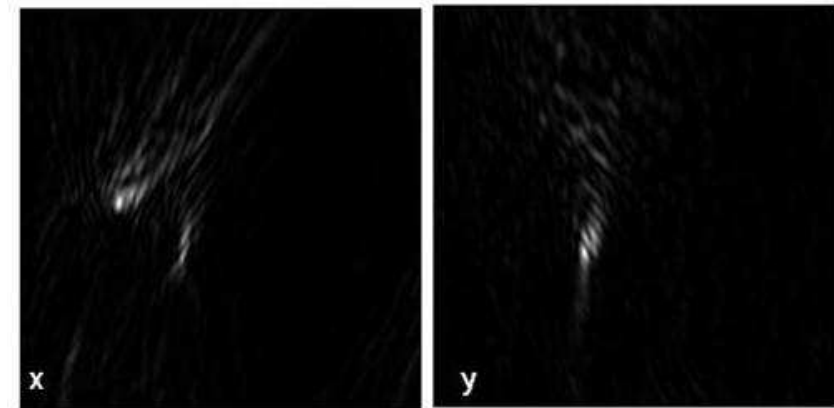
N.Warnasooriya, F. Joud et al., submitted to Optics Express



Coupes dans la reconstruction 3D :

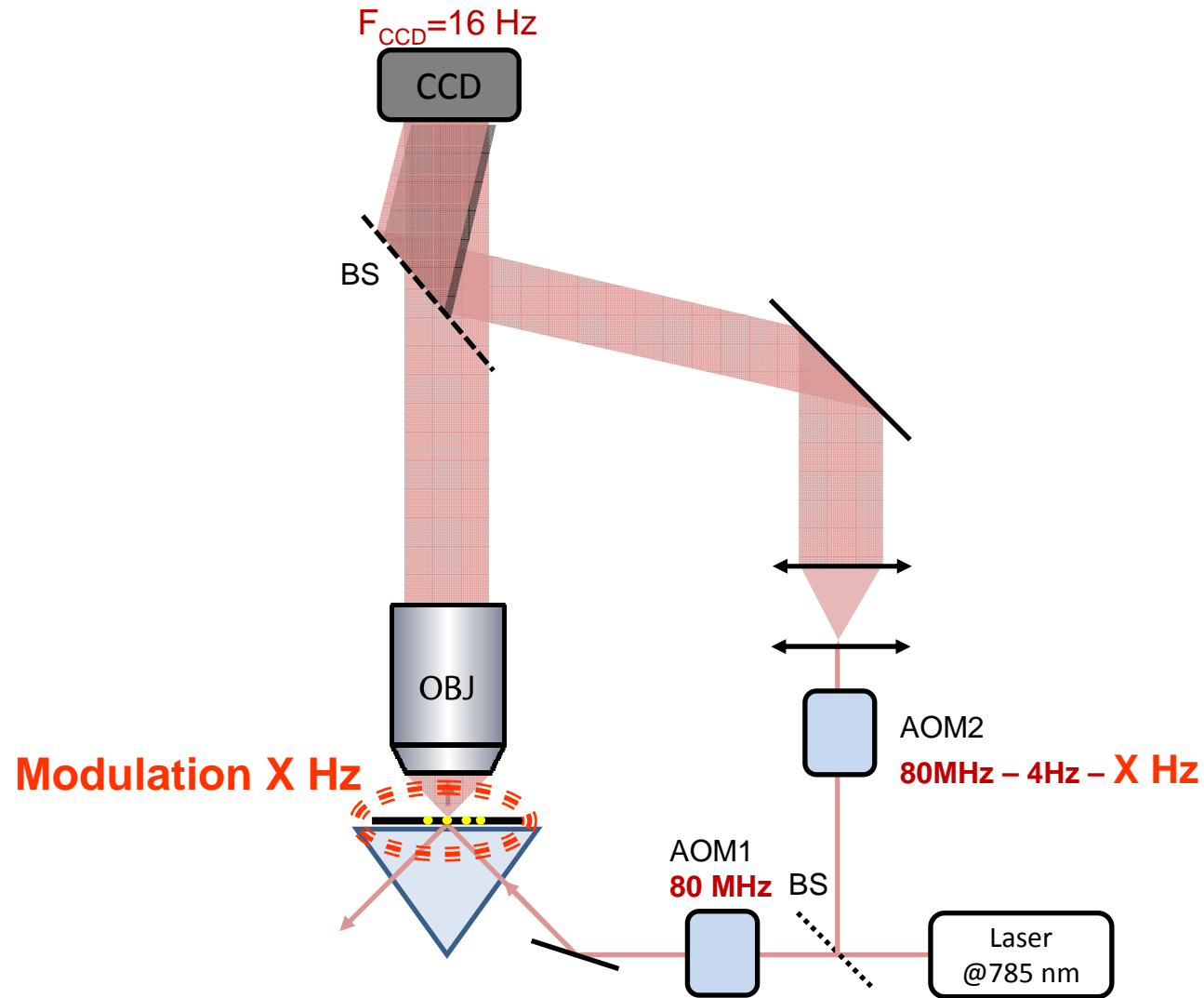


Bille



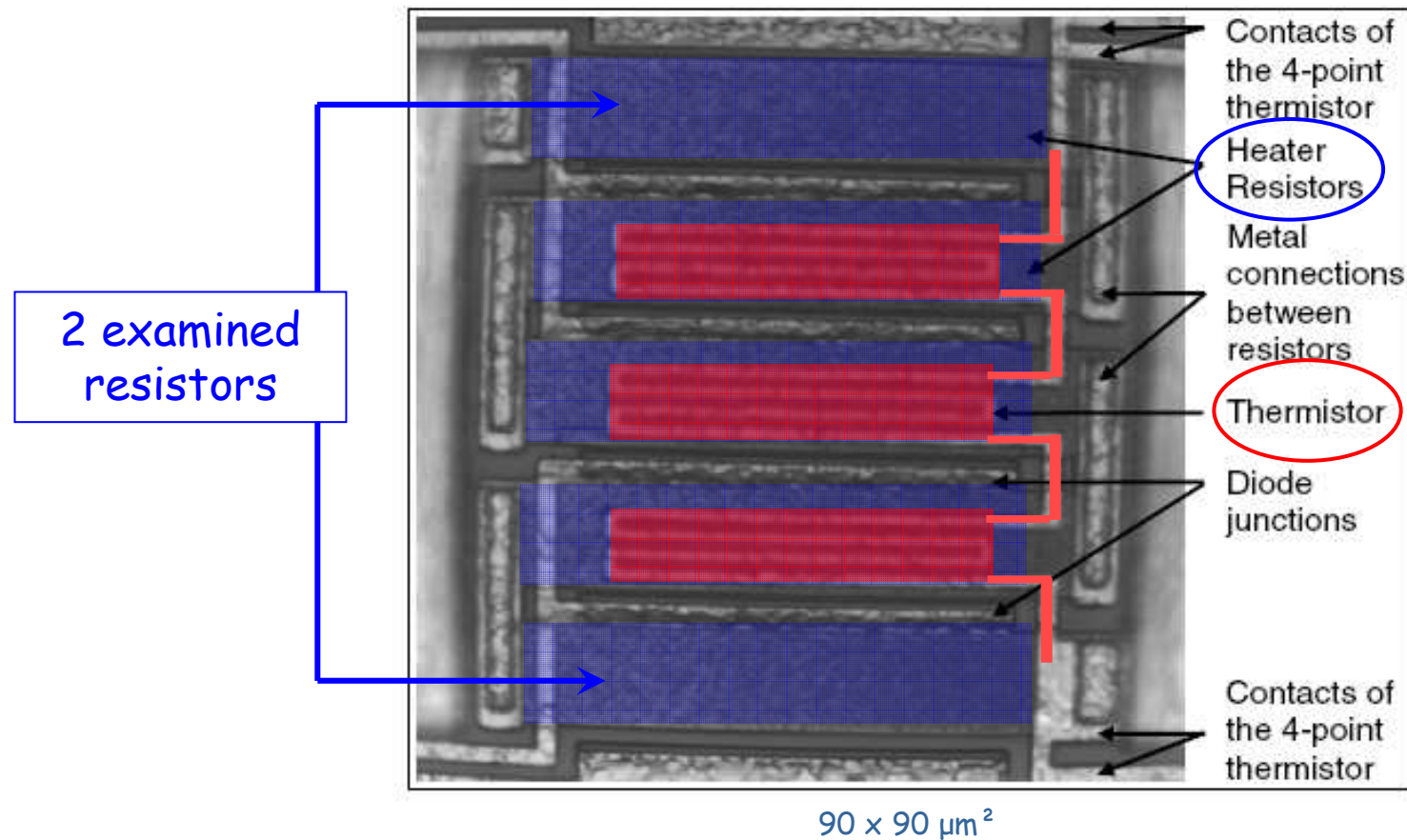
cellule

D'autres types de modulations ?



Test-Sample

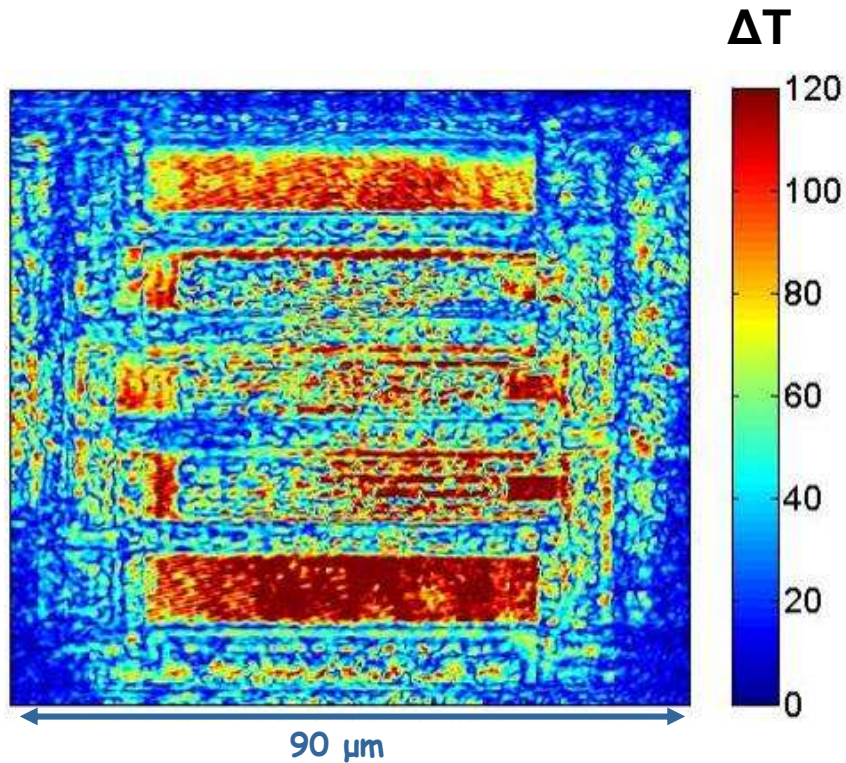
Integrated circuit consisting of 5 resistors: $R_{\text{Heat}} \approx 500 \Omega$



Imaging and Calibration

$$\Delta f = \frac{1}{4} \cdot f_{\text{CCD}} + F_H$$

Heater ON : $F_{\text{VAR}} = F_H - \text{const.}$



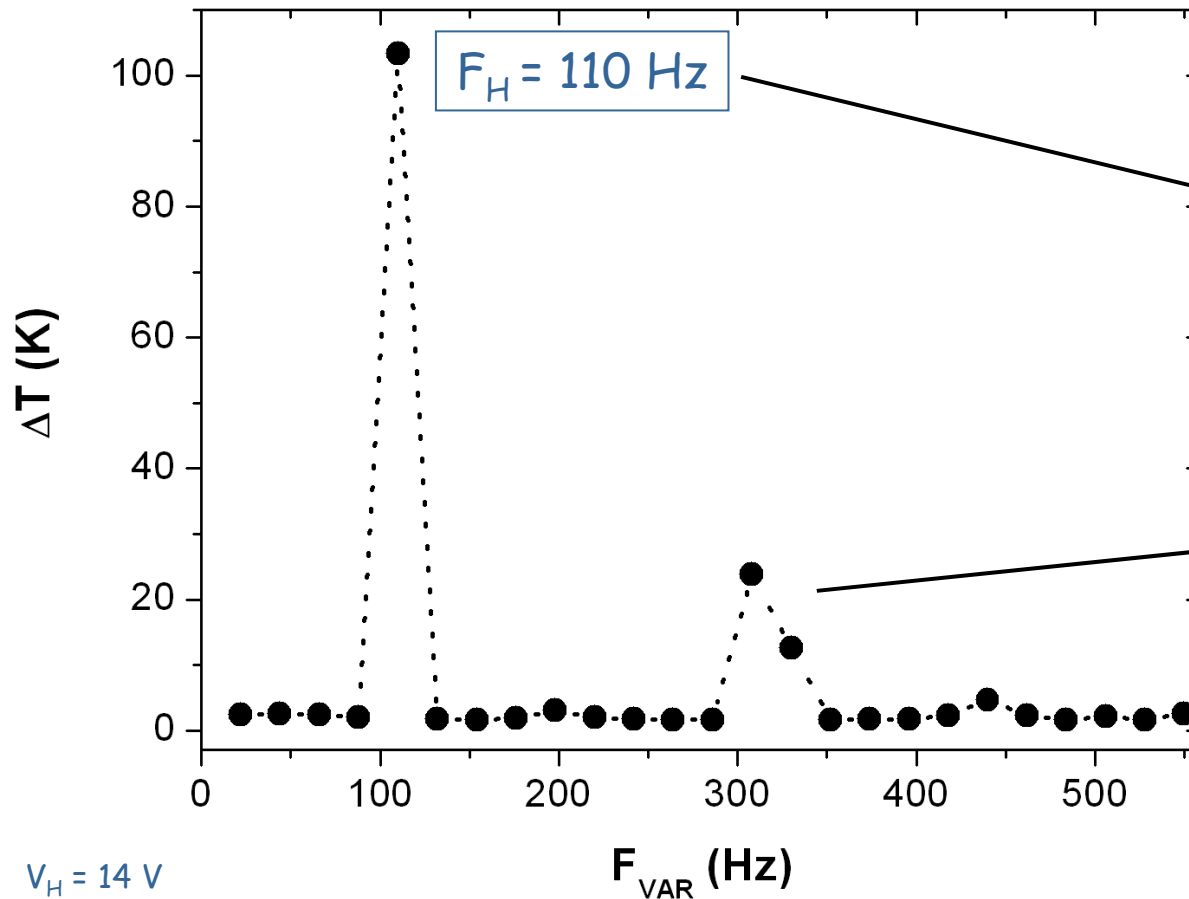
- Accumulation time : 15 sec
- Definition: 410 x 410 pixel

- Temperature resolution:
 $\Delta T = 0.35 \text{ K}$ for acquisition time of $\sim 15 \text{ sec}$
 $\Delta T = 0.70 \text{ K}$ for acquisition time of $< 5 \text{ sec}$
- Resolution = diffraction limit ($\lambda / (2 \cdot \text{NA})$)

Thermal response of a sine wave excitation

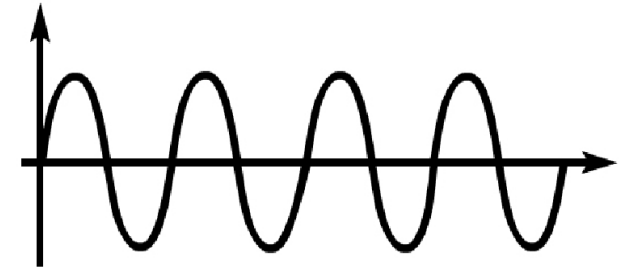
$$3. \Delta f = \frac{1}{4} \cdot f_{CCD} + F_{VAR}$$

frequency-domain :



$V_H = 14$ V

$V(t)$ Heater ON : $F_H = 110$ Hz, sinus



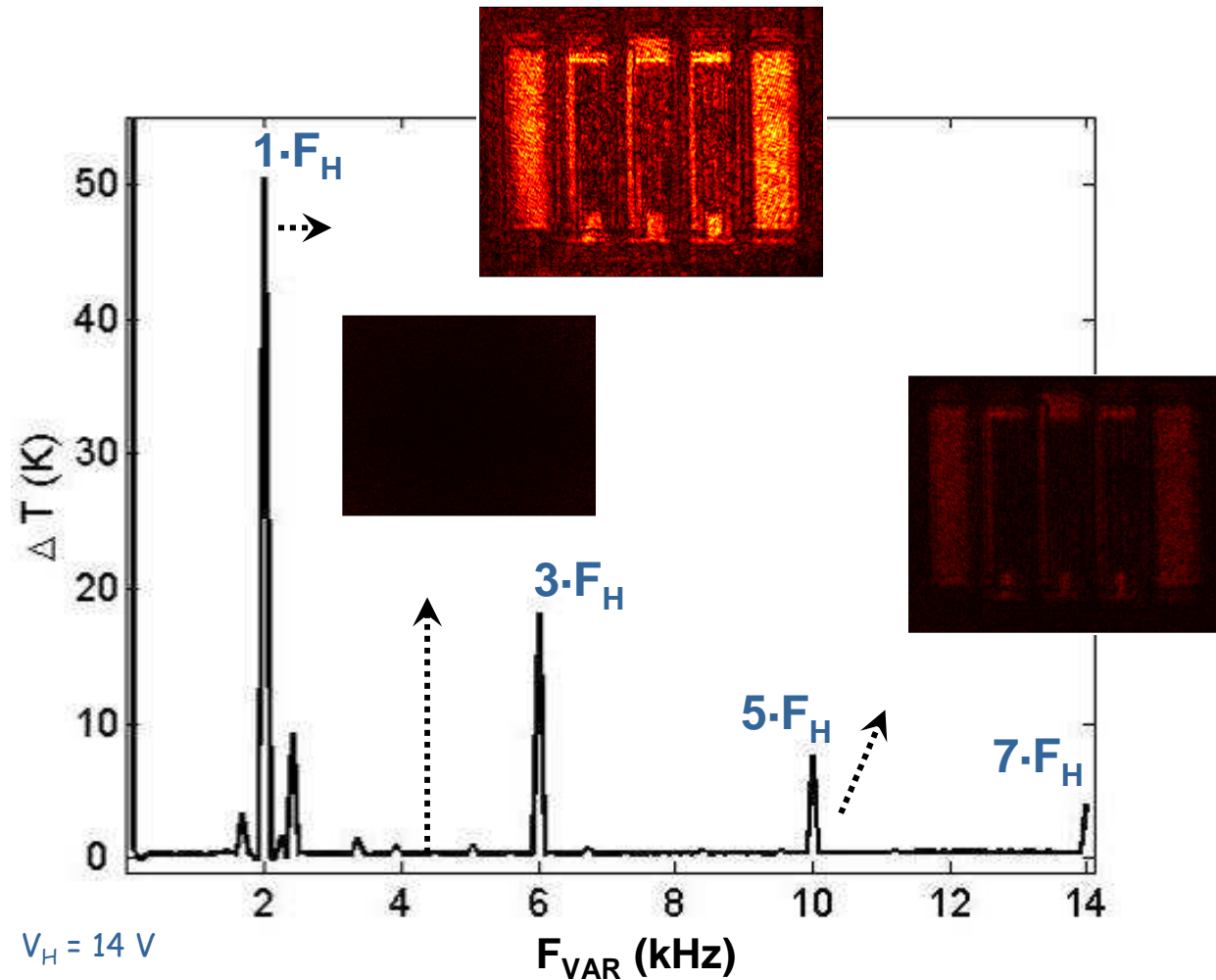
Peak at $F_{VAR} = 110$ Hz ($= F_H$)

Peaks at $F_{VAR} > 110$ Hz
→ parasitic signals

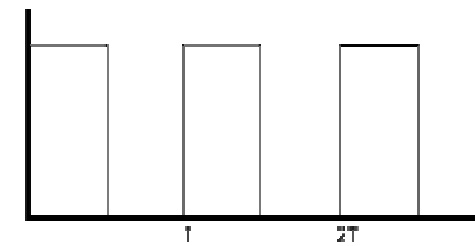
Thermal square wave excitation

$$3. \Delta f = \frac{1}{4} \cdot f_{\text{CCD}} + F_{\text{VAR}}$$

Heater ON: $F_H = 2$ kHz, square wave



$V(t)$



→ Harmonics at

$$F_{\text{VAR}} = (2n-1) \cdot F_H$$